

(19) World Intellectual Property Organization
International Bureau



(43) International Publication Date
19 June 2008 (19.06.2008)

PCT

(10) International Publication Number
WO 2008/073790 A2

(51) International Patent Classification:
H01B 3/56 (2006.01)

(21) International Application Number:
PCT/US2007/086568

(22) International Filing Date:
6 December 2007 (06.12.2007)

(25) Filing Language: English

(26) Publication Language: English

(30) Priority Data:
11/637,657 12 December 2006 (12.12.2006) US

(71) Applicant (for all designated States except US): **HONEYWELL INTERNATIONAL INC.** [US/US]; Law Department AB/2B, 101 Columbia Road, Morristown, NJ 07962 (US).

(72) Inventors; and

(75) Inventors/Applicants (for US only): **LULY, Matthew H.** [US/US]; 5423 Bridlewood Lane, Hamburg, New York 14075 (US). **RICHARD, Robert G.** [US/US]; 4331 parker Road, Hamburg, New York 14210 (US).

(74) Agent: **BEATUS, Carrie**; Honeywell International Inc., Law Department AB/2B, 101 Columbia Road, Morristown, New Jersey 07962 (US).

(81) Designated States (unless otherwise indicated, for every kind of national protection available): AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BH, BR, BW, BY, BZ, CA, CH, CN, CO, CR, CU, CZ, DE, DK, DM, DO, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, GT, HN, HR, HU, ID, IL, IN, IS, JP, KE, KG, KM, KN, KP, KR, KZ, LA, LC, LK, LR, LS, LT, LU, LY, MA, MD, ME, MG, MK, MN, MW, MX, MY, MZ, NA, NG, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RS, RU, SC, SD, SE, SG, SK, SL, SM, SV, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, ZA, ZM, ZW.

(84) Designated States (unless otherwise indicated, for every kind of regional protection available): ARIPO (BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM, ZW), Eurasian (AM, AZ, BY, KG, KZ, MD, RU, TJ, TM), European (AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IS, IT, LT, LU, LV, MC, MT, NL, PL, PT, RO, SE, SI, SK, TR), OAPI (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD, TG).

Published:

— without international search report and to be republished upon receipt of that report



WO 2008/073790 A2

(54) Title: GASEOUS DIELECTRICS WITH LOW GLOBAL WARMING POTENTIALS

(57) Abstract: A dielectric gaseous compound which exhibits the following properties: a boiling point in the range between about -20°C to about -273°C; non-ozone depleting; a GWP less than about 22,200; chemical stability, as measured by a negative standard enthalpy of formation (dHf < 0); a toxicity level such that when the dielectric gas leaks, the effective diluted concentration does not exceed its PEL; and a dielectric strength greater than air.

GASEOUS DIELECTRICS WITH LOW GLOBAL WARMING POTENTIALS

5 **1. FIELD**

The present disclosure relates generally to a class of gaseous dielectric compounds having low global warming potentials (GWP). In particular, such gaseous dielectric compounds exhibits the following properties: a boiling point in the range between about -20°C to about -273°C; low, preferably non-ozone
10 depleting; a GWP less than about 22,200; chemical stability, as measured by a negative standard enthalpy of formation ($\Delta H_f < 0$); a toxicity level such that when the dielectric gas leaks, the effective diluted concentration does not exceed its PEL, e.g., a PEL greater than about 0.3 ppm by volume (i.e., an Occupational Exposure Limit (OEL or TLV) of greater than about 0.3 ppm); and a dielectric
15 strength greater than air. These gaseous dielectric compounds are particularly useful as insulating-gases for use with electrical equipment, such as gas-insulated circuit breakers and current-interruption equipment, gas-insulated transmission lines, gas-insulated transformers, or gas-insulated substations.

20

2. BACKGROUND

Sulfur hexafluoride (SF_6) has been used as a gaseous dielectric (insulator) in high voltage equipment since the 1950s. It is now known that
25 SF_6 is a potent greenhouse warming gas with one of the highest global warming potentials (GWP) known. Because of its high GWP, it is being phased out of all frivolous applications. However, there is currently no known substitute for SF_6 in high voltage equipment. The electrical industry has taken steps to reduce the leak rates of equipment, monitor usage, increase recycling,
30 and reduce emissions to the atmosphere. However, it would still be advantageous to find a substitute for SF_6 in electrical dielectric applications.

The basic physical and chemical properties of SF₆, its behavior in various types of gas discharges, and its uses by the electric power industry have been broadly investigated.

5 In its normal state, SF₆ is chemically inert, non-toxic, non-flammable, non-explosive, and thermally stable (it does not decompose in the gas phase at temperatures less than 500°C). SF₆ exhibits many properties that make it suitable for equipment utilized in the transmission and distribution of electric power. It is a strong electronegative (electron attaching) gas both at room
10 temperature and at temperatures well above ambient, which principally accounts for its high dielectric strength and good arc-interruption properties. The breakdown voltage of SF₆ is nearly three times higher than air at atmospheric pressure. Furthermore, it has good heat transfer properties and it readily reforms itself when dissociated under high gas-pressure conditions in an
15 electrical discharge or an arc (i.e., it has a fast recovery and it is self-healing). Most of its stable decomposition byproducts do not significantly degrade its dielectric strength and are removable by filtering. It produces no polymerization, carbon, or other conductive deposits during arcing, and its is chemically compatible with most solid insulating and conducting materials used
20 in electrical equipment at temperatures up to about 200°C.

Besides its good insulating and heat transfer properties, SF₆ has a relatively high pressure when contained at room temperature. The pressure required to liquefy SF₆ at 21°C is about 2100 kPa; its boiling point is
25 reasonably low, -63.8°C, which allows pressures of 400 kPa to 600 kPa (4 to 6 atmospheres) to be employed in SF₆-insulated equipment. It is easily liquefied under pressure at room temperature allowing for compact storage in gas cylinders. It presents no handling problems, is readily available, and reasonably inexpensive.

30

SF₆ replaced air as a dielectric in gas insulated equipment based on characteristics such as insulation ability, boiling point, compressibility, chemical stability and non-toxicity. They have found that pure SF₆, or SF₆-nitrogen mixtures are the best gases to date.

5

However, SF₆ has some undesirable properties: it can form highly toxic and corrosive compounds when subjected to electrical discharges (e.g., S₂F₁₀, SOF₂); non-polar contaminants (e.g., air, CF₄) are not easily removed from it; its breakdown voltage is sensitive to water vapor, conducting particles, and conductor surface roughness; and it exhibits non-ideal gas behavior at the lowest temperatures that can be encountered in the environment, i.e., in cold climatic conditions (about -50°C), SF₆ becomes partially liquefied at normal operating pressures (400 kPa to 500 kPa). SF₆ is also an efficient infrared (IR) absorber and due to its chemical inertness, is not rapidly removed from the earth's atmosphere. Both of these latter properties make SF₆ a potent greenhouse gas, although due to its chemical inertness (and the absence of chlorine and bromine atoms in the SF₆ molecule) it is benign with regard to stratospheric ozone depletion.

That is, greenhouse gases are atmospheric gases which absorb a portion of the infrared radiation emitted by the earth and return it to earth by emitting it back. Potent greenhouse gases have strong infrared absorption in the wavelength range from approximately 7 μm to 13 μm. They occur both naturally in the environment (e.g., H₂O, CO₂, CH₄, N₂O) and as man-made gases that may be released (e.g., SF₆; perfluorinated compound (PFC); combustion products such as CO₂, nitrogen, and sulfur oxides). The effective trapping of long-wavelength infrared radiation from the earth by the naturally occurring greenhouse gases, and its reradiation back to earth, results in an increase of the average temperature of the earth's surface. Mans impact on climate change is an environmental issue that has prompted the implementation

30

of the Kyoto Protocol regulating the emissions of man made greenhouse gases in a number of countries.

SF₆ is an efficient absorber of infrared radiation, particularly at
5 wavelengths near 10.5 μm. Additionally, unlike most other naturally occurring
green house gases (e.g., CO₂, CH₄), SF₆ is only slowly decomposed; therefore
its contribution to global warming is expected to be cumulative and long
lasting. The strong infrared absorption of SF₆ and its long lifetime in the
environment are the reasons for its extremely high global warming potential
10 which for a 100-year time horizon is estimated to be approximately 22,200
times greater (per unit mass) than that of CO₂, the predominant contributor to
the greenhouse effect. The concern about the presence of SF₆ in the
environment derives exclusively from this very high value of its potency as a
greenhouse gas.

15
Accordingly, many in the electrical equipment industry have spent
substantial time and effort seeking suitable replacement gases to reduce the use
of SF₆ in high voltage electrical equipment. To date, the possible replacement
gases have been identified as (i) mixtures of SF₆ and nitrogen for which a large
20 amount of research results are available; (ii) gases and mixtures (e.g., pure
nitrogen, low concentrations of SF₆ in N₂, and SF₆-He mixtures) for which a
smaller yet significant amount of data is available; and (iii) potential gases for
which little experimental data is available.

25
Some replacements which have been proposed have higher GWPs than
SF₆. For example, CF₃SF₅ falls into this category. Because of fugitive
emissions in the manufacture, transportation, filling and use of such chemicals,
they should be avoided.

30

However, the present inventors have determined that given the environmental difficulty of SF₆, it is necessary to relax certain of the requirements traditionally held as important and accept as an alternative gas, compromise candidates with a lower GWP. For example, gases which are non-
5 toxic are often inert with long atmospheric lifetimes which can yield high GWP. By accepting a somewhat more reactive gas than SF₆, the GWP can be greatly reduced. It may also be necessary to accept slightly more toxic materials in order to find the best alternative in these applications. Such an increase in toxicity can be offset by reducing equipment leak rates or installing
10 monitoring equipment. In some cases, the gases discovered by the present inventors as suitable alternatives to SF₆ are show to be efficient at low levels and can be mixed with nitrogen and/or another non-toxic gas to give dielectrics with greatly reduced toxicity and acceptably low GWPs.

15 The unique gaseous compounds discovered by the present inventors for use as substitutes for SF₆ can be used in some existing electrical equipment, although they would preferably be used in specific electrical equipment optimized for them. The gaseous compounds of the present disclosure are preferably used in pure form, but can also be used as part of an azeotrope, or a
20 mixture with an appropriate second gas, such as nitrogen, CO₂ or N₂O.

SUMMARY

A dielectric gaseous compound which exhibits the following properties: a boiling point in the range between about -20°C to about -273°C; low,
25 preferably non-ozone depleting; a GWP less than about 22,200; chemical stability, as measured by a negative standard enthalpy of formation ($\Delta H_f < 0$); a toxicity level such that when the dielectric gas leaks, the effective diluted concentration does not exceed its PEL (i.e., an Occupational Exposure Limit (OEL or TLV) of at least about 0.3 ppm); and a dielectric strength greater than
30 air.

The dielectric gaseous compound is at least one compound selected from the group consisting of:

Arsenic pentafluoride
Arsine
Diboron tetrafluoride
Diborane
Perchloric acid, 2-chloro-1,1,2,2-tetrafluoroethyl ester (9CI)
Perchloric acid, 1,2,2-trichloro-1,2-difluoroethyl ester
Trifluoroacetyl chloride
trifluoromethylisocyanide (CF₃-NC)
trifluoromethyl isocyanide
trifluoro-nitroso-ethene//Trifluor-nitroso-aethen
Tetrafluoroethene
3,3,4,4-tetrafluoro-3,4-dihydro-[1,2]diazete
(Difluoramino)difluoroacetonitril
Tetrafluorooxirane
Trifluoroacetyl fluoride
Perfluoromethylfluorformiat
trifluoro-acetyl hypofluorite
perfluoro-2-aza-1-propene
Perfluor-2-aza-1-propen (germ.)
N-Fluor-tetrafluor-1-aethanimin (germ.)
3,3-difluoro-2-trifluoromethyl-oxaziridine
bis-trifluoromethyl-diazene//hexafluoro-#cis!-azomethane
Fluoroxypentafluoroethane
bis-trifluoromethyl peroxide
1,1-Bis(fluoroxy)tetrafluoroaethan
Hexafluorodimethyl sulfide
3-fluoro-3#H!-diazirine-3-carbonitrile
Ethyne
1,2,2-trifluoro-aziridine
Ketene
(difluoro)vinylboran
(Difluor)vinylboran (germ.)
trifluoro-vinyl-silane
Ethinylsilan
ethyl-difluor-borane
Ethyl-difluor-boran (germ.)
methyl-methylen-amine
Dimethyl ether
vinyl-silane
Dimethylsilane

Chloroethyne
fluoroethyne//fluoro-acetylene
Ethanedinitrile
tetrafluoropropyne//1,3,3,3-tetrafluoropropyne
hexafluoro-oxetane
Trifluoro(trifluoromethyl)oxirane
1,1,1,3,3,3-Hexafluoropropanone
pentafluoro-propionyl fluoride//perfluoropropionyl fluoride
Trifluoromethyl trifluorovinyl ether
1-Propyne
Cyclopropane
Propane
Trimethylborane
cyanoketene
butatriene
Cyano-bispentafluorethyl-phosphin
Trimethyl-1,1,2,2-tetrafluorethylsilan
methyl diborane
Methyldiboran (germ.)
carbonyl bromide fluoride
chloro-difluoro-nitroso-methane//Chlor-difluor-nitroso-methan
chloroperoxytrifluoromethane
carbonylchlorid-fluorid
Carbonylchloridfluorid (germ.)
3,3-difluoro-3#H!-diazirine
difluoro diazomethane
Difluordiazomethan (germ.)
Carbonyl fluoride
Difluordioxiran
difluoro-(3-fluoro-3#H!-diazirin-3-yl)-amine
trifluoromethylazide
Trifluormethylazid (germ.)
tetrafluoro-diaziridine
Fluorperoxytrifluormethan
Bis(fluoroxy)difluormethan
Trifluormethyl-phosphonylfluorid
Cyanogen fluoride
Trifluormethylphosphane (germ.)
Diazomethane
formaldehyde//Formalin
(methyl)difluoroborane
(Methyl)difluorboran (germ.)
Chloromethane
methylphosphonous acid difluoride//difluoro-methyl-phosphine
trifluoro-methoxy-silane

Methylhypofluorid
Methane
Methylsilane
#Si!-bromo-#Si!,#Si!'-methanediyl-bis-silane
#Si!-iodo-#Si!,#Si!'-methanediyl-bis-silane
Difluormethylnitrit
trifluoromethanol
Formyl fluoride
Cyanic acid
Chlorine
Chlorine fluoride
Chlorine trioxide fluoride
carbon oxide selenide//Kohlenoxidselenid
Fluorine
Difluorosilane
Fluorine oxide
fluorine peroxide
Sulfuryl fluoride
sulphur difluoride
Phosphorus trifluoride oxide
Phosphorus trifluoride sulfide
tetrafluorophosphorane
Tetrafluorohydrazine
Sulfur tetrafluoride
hexafluoro disiloxane
Hexafluordisiloxan (germ.)
Nitryl fluoride
Hydrogen
Hydrogen selenide
Phosphorus trihydride
Germanium hydride
Silane
Tin tetrahydride
Oxygen
Ozone
Antimony monophosphide
Disilicon monophosphide
Radon
Argon
Trifluoroborane
Hydrogen bromide
Bromopentafluoroethane
Chlorotrifluoroethene
Trifluoroacetonitrile
trifluoromethyl isocyanate

trifluoromethyl thiocarbonyl fluoride
 Trifluormethylthiocarbonylfluorid (germ.)
 pentafluoro-nitroso-ethane//Pentafluor-nitroso-aethan
 (trifluoromethyl-carbonyl)-difluoro-amine
 Hexafluoroethane
 Bis-trifluormethyl-nitroxid
 bis-trifluoromethyl ether
 bis(trifluoromethyl)tellurium
 bis(trifluoromethyl) ditelluride
 N,N-Difluor-pentafluoraethylamin (germ.)
 N-Fluor-bis(trifluormethyl)-amin (germ.)
 N-Fluor-N-trifluormethoxy-perfluormethylamin (germ.)
 fluoroformyl cyanide
 1-chloro-1-fluoro-ethene//1-Chlor-1-fluor-aethen//1-chloro-1-fluoroethylene
 1,1-Difluoroethene
 #trans!-1,2-difluoro-ethene//#trans!-vinylene difluoride//(E)-1,2-
 difluoroethylene//(E)-1,2-difluoro-ethene//#trans!-vinylene fluoride
 1,2-difluoro-ethene//#cis!-vinylene difluoride//1,2-Difluor-aethen//vinylene
 fluoride
 #cis!-1,2-difluoro-ethene//#cis!-vinylene difluoride//(Z)-1,2-
 difluoroethylene//(Z)-1,2-difluoro-ethene//#cis!-vinylene fluoride
 1,1,1,2-Tetrafluoroethane
 1,1,2,2-Tetrafluoroethane
 Fluoroethene
 1,1,1-Trifluoroethane
 Ether, methyl trifluoromethyl
 Ethene
 1,1-Difluoroethane
 Fluoroethane
 Ethane
 fluoro-dimethyl-borane
 Disiloxane, 1,1,3,3-tetrafluoro-1,3-dimethyl-
 Trifluoroethene
 trifluoroacetaldehyde//Trifluor-acetaldehyd
 Pentafluoroethane
 Difluoromethyl trifluoromethyl ether
 Tris(trifluoromethyl)bismuth
 tetrafluoropropadiene//tetrafluoro-allene//1,1,3,3-tetrafluoro-1,2-propadiene
 tetrafluorocyclopropene
 Perfluoropropionylidid
 pentafluoro-propionitrile//pentafluoropropionitrile
 hexafluoro-cyclopropane//Hexafluor-cyclopropan//freon-#C!216
 Hexafluoropropylene
 hexafluoro-[1,3]dioxolane
 Octafluoropropane

Perfluormethylethylether
 1,1-difluoro-propadiene//allenylidene difluoride//1,1-difluoro-allene
 2,3,3,3-tetrafluoro-propene//HFO-1234yf
 trans HFO-1234ze
 3,3,3-Trifluoropropene
 cyclopropene
 Allene
 1,1-difluoro-propene//propenylidene difluoride//1,1-Difluor-propen
 methylketene
 2-fluoropropene
 1-Propene
 DL-2-aminopropanoic acid
 3,3,3-trifluoro-propyne//3,3,3-Trifluor-propin//trifluoromethyl-ethyne//3,3,3-
 trifluoro-1-propyne
 1,1,3,3,3-pentafluoro-propene//1,1,3,3,3-Pentafluor-propen
 1,2,3,3,3-pentafluoro-propene
 1,1,1,4,4,4-hexafluoro-2-butyne
 1,1,4,4-tetrafluoro-butane-2,3-dione
 Trifluormethylhypochlorit
 Chlor-difluor-methyl-hypofluorit
 N-Chlor-N-fluor-trifluormethylamin (germ.)
 Chlordifluordifluoraminoethan
 thiocarbonyl difluoride
 Thiocarbonyldifluorid (germ.)
 selenocarbonyl difluoride
 Trifluoriodomethane
 N-Fluor-difluormethanimin (germ.)
 trifluoro-nitroso-methane//Trifluor-nitroso-methan
 difluoro-carbamoyl fluoride
 trifluoro-nitro-methane//Trifluor-nitro-methan//fluoropicrin
 Tetrafluoromethane
 Tetrafluorformamidin (germ.)
 tetrafluorourea
 hypofluorous acid trifluoromethyl ester//Hypofluorigsaeure-
 trifluormethylester//trifluoromethyl hypofluorite
 trifluoromethanesulfonyl fluoride
 N,N-Difluor-trifluormethylamin (germ.)
 Trifluormethoxydifluorammin
 (Difluoraminoxy)difluormethylhypofluorit
 sulfurcyanide pentafluoride
 Schwefelcyanid-pentafluorid (germ.)
 difluoro-trifluoromethyl-phosphine
 Hexafluormethandiamin
 perfluoro methyl silane
 Perfluormethylsilan (germ.)

Trifluormethyl-tetrafluorophosphan (germ.)
Difluoromethane
Fluoriodomethane
fluoromethane//methyl fluoride//Fluor-methan//freon-41
trifluoromethyl-silane" CF₃SiH₃
methyltrifluorosilane
difluoro-methyl-silane
fluoro-methyl-silane
methylgermane
Difluorformimin
Trifluoromethane
trifluoromethane thiol
Trifluormethanthiol (germ.)
N,N,1,1-Tetrafluormethylamin
difluoro dichlorosilane
Difluordichlorsilan (germ.)
difluoro chlorosilane
Difluorchlorsilan (germ.)
Phosphorus chloride difluoride
Chlorotrifluorosilane
Hydrogen chloride
Chlorosilane
Carbon monoxide
Carbon dioxide
Carbonyl sulfide
Difluoramine
trans-Difluorodiazine
cis-Difluorodiazine
Thionyl fluoride
Trifluorosilane
Nitrogen trifluoride
Trifluoramine oxide
thiazyl trifluoride
Phosphorus trifluoride
Germanium(IV) fluoride
Tetrafluorosilane
Phosphorus pentafluoride
Selenium hexafluoride
Tellurium hexafluoride
fluorosilane
Nitrosyl fluoride
Fluorine nitrate
Hydrogen sulfide
Ammonia
Helium

Hydrogen iodide
 Krypton
 Nitrogen
 dinitrogen oxide
 Neon
 Nitrogen oxide; and
 Xenon

More preferably, the dielectric compounds can be selected from the group consisting of:

Argon
 Trifluoroborane
 Hydrogen bromide
 Bromopentafluoroethane
 Chlorotrifluoroethene
 Trifluoroacetonitrile
 trifluoromethyl isocyanate
 trifluoromethyl thiocarbonyl fluoride
 Trifluormethylthiocarbonylfluorid (germ.)
 pentafluoro-nitroso-ethane//Pentafluor-nitroso-aethan
 (trifluoromethyl-carbonyl)-difluoro-amine
 Hexafluoroethane
 Bis-trifluormethyl-nitroxid
 bis-trifluoromethyl ether
 bis(trifluoromethyl)tellurium
 bis(trifluoromethyl) ditelluride
 N,N-Difluor-pentafluoraethylamin (germ.)
 N-Fluor-bis(trifluormethyl)-amin (germ.)
 N-Fluor-N-trifluormethoxy-perfluormethylamin (germ.)
 fluoroformyl cyanide
 1-chloro-1-fluoro-ethene//1-Chlor-1-fluor-aethen//1-chloro-1-fluoroethylene
 1,1-Difluoroethene
 #trans!-1,2-difluoro-ethene//#trans!-vinylene difluoride//(E)-1,2-difluoroethylene//(E)-1,2-difluoro-ethene//#trans!-vinylene fluoride
 1,2-difluoro-ethene//#cis!-vinylene difluoride//1,2-Difluor-aethen//vinylene fluoride
 #cis!-1,2-difluoro-ethene//#cis!-vinylene difluoride//(Z)-1,2-difluoroethylene//(Z)-1,2-difluoro-ethene//#cis!-vinylene fluoride
 1,1,1,2-Tetrafluoroethane
 1,1,2,2-Tetrafluoroethane
 Fluoroethene
 1,1,1-Trifluoroethane
 Ether, methyl trifluoromethyl

Ethene
 1,1-Difluoroethane
 Fluoroethane
 Ethane
 fluoro-dimethyl-borane
 Disiloxane, 1,1,3,3-tetrafluoro-1,3-dimethyl-
 Trifluoroethene
 trifluoroacetaldehyde//Trifluor-acetaldehyd
 Pentafluoroethane
 Difluoromethyl trifluoromethyl ether
 Tris(trifluoromethyl)bismuth
 tetrafluoropropadiene//tetrafluoro-allene//1,1,3,3-tetrafluoro-1,2-propadiene
 tetrafluorocyclopropene
 Perfluoropropionylidid
 pentafluoro-propionitrile//pentafluoropropionitrile
 hexafluoro-cyclopropane//Hexafluor-cyclopropan//freon-#C!216
 Hexafluoropropylene
 hexafluoro-[1,3]dioxolane
 Octafluoropropane
 Perfluormethylethylether
 1,1-difluoro-propadiene//allenylidene difluoride//1,1-difluoro-allene
 2,3,3,3-tetrafluoro-propene//HFO-1234yf
 trans HFO-1234ze
 3,3,3-Trifluoropropene
 cyclopropene
 Allene
 1,1-difluoro-propene//propenylidene difluoride//1,1-Difluor-propen
 methylketene
 2-fluoropropene
 1-Propene
 DL-2-aminopropanoic acid
 3,3,3-trifluoro-propyne//3,3,3-Trifluor-propin//trifluoromethyl-ethyne//3,3,3-
 trifluoro-1-propyne
 1,1,3,3,3-pentafluoro-propene//1,1,3,3,3-Pentafluor-propen
 1,2,3,3,3-pentafluoro-propene
 1,1,1,4,4,4-hexafluoro-2-butyne
 1,1,4,4-tetrafluoro-butane-2,3-dione
 Trifluormethylhypochlorit
 Chlor-difluor-methyl-hypofluorit
 N-Chlor-N-fluor-trifluormethylamin (germ.)
 Chlordifluordifluoraminoethan
 thiocarbonyl difluoride
 Thiocarbonyldifluorid (germ.)
 selenocarbonyl difluoride
 Trifluoriodomethane

N-Fluor-difluormethanimin (germ.)
trifluoro-nitroso-methane//Trifluor-nitroso-methan
difluoro-carbamoyl fluoride
trifluoro-nitro-methane//Trifluor-nitro-methan//fluoropicrin
Tetrafluoromethane
Tetrafluorformamidin (germ.)
tetrafluorourea
hypofluorous acid trifluoromethyl ester//Hypofluorigsaeure-
trifluormethylester//trifluoromethyl hypofluorite
trifluoromethanesulfonyl fluoride
N,N-Difluor-trifluormethylamin (germ.)
Trifluormethyloxydifluoramin
(Difluoraminoxy)difluormethylhypofluorit
sulfurcyanide pentafluoride
Schwefelcyanid-pentafluorid (germ.)
difluoro-trifluoromethyl-phosphine
Hexafluormethandiamin
perfluoro methyl silane
Perfluormethylsilan (germ.)
Trifluormethyl-tetrafluorphosphoran (germ.)
Difluoromethane
Fluoroiodomethane
fluoromethane//methyl fluoride//Fluor-methan//freon-41
trifluoromethyl-silane" CF₃SiH₃
methyltrifluorosilane
difluoro-methyl-silane
fluoro-methyl-silane
methylgermane
Difluorformimin
Trifluoromethane
trifluoromethane thiol
Trifluormethanthiol (germ.)
N,N,1,1-Tetrafluormethylamin
difluoro dichlorosilane
Difluordichlorsilan (germ.)
difluoro chlorosilane
Difluorchlorsilan (germ.)
Phosphorus chloride difluoride
Chlorotrifluorosilane
Hydrogen chloride
Chlorosilane
Carbon monoxide
Carbon dioxide
Carbonyl sulfide
Difluoramine

trans-Difluorodiazine
cis-Difluorodiazine
Thionyl fluoride
Trifluorosilane
Nitrogen trifluoride
Trifluoramine oxide
thiazyl trifluoride
Phosphorus trifluoride
Germanium(IV) fluoride
Tetrafluorosilane
Phosphorus pentafluoride
Selenium hexafluoride
Tellurium hexafluoride
fluorosilane
Nitrosyl fluoride
Fluorine nitrate
Hydrogen sulfide
Ammonia
Helium
Hydrogen iodide
Krypton
Nitrogen
Nitrous oxide
Neon
Nitrogen oxide; and
Xenon

The dielectric gaseous compound is optionally form as an azeotrope, which imparts many advantages in handling the mixture. Preferred mixtures for dielectric gaseous compound contain one additional gas selected from the group
5 consisting of: nitrogen, CO₂ and N₂O.

The present disclosure also includes an insulation-gas for use in electrical equipment, wherein said insulation-gas is a dielectric gaseous compound which
10 exhibits the following properties: a boiling point in the range between about -20°C to about -273°C; low, preferably non-ozone depleting; a GWP less than about 22,200; chemical stability, as measured by a negative standard enthalpy of formation (dHf < 0); a toxicity level such that when the dielectric gas leaks, the

effective diluted concentration does not exceed its PEL (i.e., Occupational Exposure Limit (OEL or TLV) of at least about 0.3 ppm); and a dielectric strength greater than air.

5 Preferably, the electrical equipment is at least one selected from the group consisting of: gas-insulated circuit breakers and current-interruption equipment, gas-insulated transmission lines, gas-insulated transformers, and gas-insulated substations.

10 **DETAILED DESCRIPTION OF THE PREFERRED EMBODIMENT.**

 The compounds of the present disclosure are useful in gaseous phase for electrical insulation and for arc quenching and current interruption equipment used in the transmission and distribution of electrical energy. Generally, there are four major types of electrical equipment which the gases of the present disclosure can be used for insulation and/or interruption purposes: (1) gas-insulated circuit breakers and current-interruption equipment, (2) gas-insulated transmission lines, (3) gas-insulated transformers, and (4) gas-insulated substations. Such gas-insulated equipment is a major component of power transmission and distribution systems all over the world. It offers significant savings in land use, is aesthetically acceptable, has relatively low radio and audible noise emissions, and enables substations to be installed in populated areas close to the loads.

 Depending on the particular function of the gas-insulated equipment, the gas properties which are the most significant vary.

 For circuit breakers the excellent thermal conductivity and high dielectric strength of such gases, along with the fast thermal and dielectric recovery (short time constant for increase in resistivity), are the main reasons for its high interruption capability. These properties enable the gas to make a rapid

transition between the conducting (arc plasma) and the dielectric state of the arc, and to withstand the rise of the recovery voltage.

For gas-insulated transformers the cooling ability, compatibility with
5 sold materials, and partial discharge characteristics, added to the dielectric characteristics, make them a desirable medium for use in this type of electrical equipment. The compounds have distinct advantages over oil insulation, including none of the fire safety problems or environmental problems related to oil, high reliability, flexible layout, little maintenance, long service life, lower
10 noise, better handling, and lighter equipment.

For gas-insulated transmission lines the dielectric strength of the gaseous medium under industrial conditions is of paramount importance, especially the behavior of the gaseous dielectric under metallic particle contamination,
15 switching and lightning impulses, and fast transient electrical stresses. These gases also have a high efficiency for transfer of heat from the conductor to the enclosure and are stable for long periods of time (e.g., 40 years). These gas-insulated transmission lines offer distinct advantages: cost effectiveness, high-carrying capacity, low losses, availability at all voltage ratings, no fire risk,
20 reliability, and a compact alternative to overhead high voltage transmission lines in congested areas that avoids public concerns with overhead transmission lines.

For gas-insulated substations, the entire substation (circuit breakers, disconnects, grounding switches, busbar, transformers, etc., are interconnected)
25 is insulated with the gaseous dielectric medium of the present disclosure, and, thus, all of the above-mentioned properties of the dielectric gas are significant.

The properties of a dielectric gas that are necessary for its use in high voltage equipment are many and vary depending on the particular application of
30 the gas and the equipment.

Intrinsic properties are those properties of a gas which are inherent in the physical atomic or molecular structure of the gas. These properties are independent of the application or the environment in which a gas is placed. One
5 of the desirable properties of a gaseous dielectric is high dielectric strength (higher, for instance than air). The gas properties that are principally responsible for high dielectric strength are those that reduce the number of electrons which are present in an electrically-stressed dielectric gas. To effect such a reduction in the electron number densities, as gas should: (i) be electronegative (remove
10 electrons by attachment over as wide an energy range as possible); it should preferably exhibit increased electron attachment with increasing electron energy and gas temperature since electrons have a broad range of energies and the gas temperature in many applications is higher than ambient; (ii) have good electron slowing-down properties (slow electrons down so that they can be captured
15 efficiently at lower energies and be prevented from generating more electrons by electron impact ionization); and (iii) have low ionization cross section and high ionization onset (prevent ionization by electron impact). Besides the above properties, there are a number of other basic properties which are necessary for the complete characterization of the dielectric gas behavior and its performance
20 in practice, e.g., secondary processes such as electron emission from surfaces by ion and photon impact; photoprocesses; absorption of photoionizing radiation (this is a controlling factor in discharge development in non-uniform fields); dissociation under electron impact decomposition; ion-molecule reactions; reactions with trace impurities; and reactions with surfaces.

25

The dielectric gas must also have the following chemical properties: high vapor pressure; high specific heat, high thermal conductivity for gas cooling; thermal stability over long periods of time for temperatures greater than 400°K; chemical stability and inertness with regard to conducting and insulating
30 materials; non-flammable; toxicity acceptable for industrial exposure; and non-

explosive. When used in mixtures, it must have appropriate thermodynamic properties for mixture uniformity, composition, and separation.

Extrinsic properties are those which describe how a gas may interact with its surroundings, or in response to external influences, such as electrical breakdown and discharges. To be used in electrical applications, a dielectric gas should: (undergo no extensive decomposition; lead to no polymerization; form no carbon or other deposits; and be non-corrosive and non-reactive to metals, insulators, spacers, and seals. In addition it should have: no byproduct with toxicity unacceptable for industrial applications; removable byproducts; and a high recombination rate for reforming itself, especially for arc interruption. Finally, the gas must be environmentally friendly, e.g., it must not contribute to global warming, must not deplete stratospheric ozone, and must not persist in the environment for long periods of time.

Specific properties of the gas under discharge and breakdown conditions include: a high breakdown voltage under uniform and non-uniform electric fields; insensitivity to surface roughness or defects and freely moving conducting particles; good insulation properties under practical conditions; good insulator flashover characteristics; good heat transfer characteristics; good recovery (rate of voltage recovery) and self-healing; no adverse reactions with moisture and common impurities; and no adverse effects on equipment, especially on spacers and electrode surfaces.

Specific properties of gaseous insulators for specific electrical equipment is set forth below:

Circuit breakers – The most significant required gas properties for arc interruption are: (i) high dielectric strength comparable to that of SF₆; (ii) high thermal conductivity; (iii) fast gas recovery; and (iv) self-healing/dielectric

integrity.

Gas-insulated transmission lines – The required properties include: (i) high dielectric strength; (ii) high vapor pressure at operating and ambient
5 temperature; (iii) chemical inertness; (iv) high thermal conductivity; (v) no thermal aging; (vi) no deposits; (vii) easily removable, non-harmful byproducts; and (viii) no unacceptable level of hazards (fire, explosion, toxicity, corrosion).

Gas-insulated transformers – The properties of the gas required for this
10 application include: (i) high dielectric strength at reasonable pressures (e.g., 500 kPa); (ii) low boiling point; (iii) acceptably low toxicity; (iv) chemical inertness; (v) good thermal stability; (vi) non-flammable; (vii) high cooling capability; (viii) good compatibility with solid materials; (ix) good partial discharge characteristics; (x) useable over a range of temperatures; and (xi) safe, easy to
15 handle, inexpensive and securely available.

The present inventors have discovered a unique series of dielectric gases for use in electric equipment applications, which exhibit many of the
aforementioned properties, which avoiding the greenhouse problems associated
20 with SF₆. Such dielectric compounds exhibit at least one of the following properties:

- A boiling point in the range between about -20°C to about -273°C
- Low, preferably, Non-ozone depleting
- A GWP less than about 22,200
- 25 • Chemical stability, as measured by a negative standard enthalpy of formation ($dH_f < 0$)
- A toxicity level such that when the working gas leaks from equipment at the manufacturer's specified maximum leak rate, the effective diluted concentration does not its PEL, i.e., does not exceed the PEL of that
30 specific compound. In general with minimal ventilation PELs greater

than about 0.3 ppm by volume are acceptable (i.e., an Occupational Exposure Limit (OEL or TLV) of at least about 0.3 ppm). OSHA sets enforceable permissible exposure limits (PELs) to protect workers against the health effects of exposure to hazardous substances. OSHA PELs are based on an 8-hour time weighted average (TWA) exposure. Approximately 500 PELs have been established. Existing PELs are contained in 29 CFR 1910.1000, the air contaminants standard. Most PELs are listed in 29 CFR 1910.1000, Table Z-1, and 29 CFR 1910.1000, Table Z-2.

- A dielectric strength greater than air.

These unique dielectric gases are at least one gas selected from the group consisting of those set forth in Table 1 below:

TABLE 1

Dielectric Compound	Structure	Name	CAS	MW	MY BP(oC)
AsF5	AsF5	Arsenic pentafluoride	7784-36-3	169.91	-52.8
AsH3	AsH3	Arsine	7784-42-1	77.95	-62.2
B2F4	B2F4	Diboron tetrafluoride	13965-73-6	97.61	-34.2
B2H6	H2B(H2)BH2	Diborane	19287-45-7	27.67	-92.3
C2Cl2F4O4	O3ClOCF2CF2Cl	Perchloric acid, 2-chloro-1,1,2,2-tetrafluoroethyl ester (9Cl)	38126-28-2	234.92	-95.0
C2Cl4F2O4	O3ClOFCFC1CFCl2	Perchloric acid, 1,2,2-trichloro-1,2-difluoroethyl ester	38126-29-3	267.83	-35.0
C2ClF3O	CF3CCl(O)	Trifluoroacetyl chloride	354-32-5	132.47	-27.0
C2F3N	(CF3)-NC	trifluoromethylisocyanide (CF3-NC)	19480-01-4	95.02	-84.0
C2F3N	CF3-NC	trifluoromethyl isocyanide	19480-01-4	95.02	-35.0
C2F3NO	CF2=CF-NO	trifluoro-nitroso-ethene//Trifluor-nitroso-aethen	2713-04-4	111.02	-23.7
C2F4	C2F4	Tetrafluoroethene	116-14-3	100.02	-75.6
C2F4N2	cyclo -CF2-N=N-CF2-	3,3,4,4-tetrafluoro-3,4-dihydro-[1,2]diazete	694-60-0	128.03	-36.0
C2F4N2	NF2-CF2-CN	(Difluoramino)difluoraceto	5131-88-4	128.03	-32.0

		nitril			
C2F4O	O(CF2CF2)	Tetrafluorooxirane	694-17-7	116.01	-63.5
C2F4O	CF3CF(O)	Trifluoroacetyl fluoride	354-34-7	116.01	-59.0
C2F4O2	FC(O)OCF3	Perfluoromethylfluorformiat	3299-24-9	132.01	-33.0
C2F4O2	CF3C(O)OF	trifluoro-acetyl hypofluorite	359-46-6	132.01	-25.0
C2F5N	CF3N=CF2	perfluoro-2-aza-1-propene Perfluor-2-aza-1-propen (germ.)		133.02	-34.0
C2F5N	CF3CFNF	N-Fluor-tetrafluor-1- aethanimin (germ.)	758-35-0	133.02	-32.0
C2F5NO	cyclo(-CF2- N(CF3)-O-)	3,3-difluoro-2- trifluoromethyl-oxaziridine	60247-20-3	149.02	-34.8
C2F6N2	(CF3)N=N(CF 3)	bis-trifluoromethyl- diazene//hexafluoro-#cis!- azomethane	372-63-4	166.03	-20.0
C2F6O	C2F5OF	Fluoroxypentafluoroethane	3848-94-0	154.01	-50.0
C2F6O2	CF3-O-O-CF3	bis-trifluoromethyl peroxide	927-84-4	170.01	-40.0
C2F6O2	CF3C(OF)2F	1,1- Bis(fluoroxy)tetrafluoroeth an	16329-92-3	170.01	-35.0
C2F6S	(CF3)2S	Hexafluorodimethyl sulfide	371-78-8	170.08	-22.2
C2FN3	(-N=N-)CF(CN)	3-fluoro-3#H!-diazirine-3- carbonitrile	4849-85-8	85.04	-30.0
C2H2	HCCH	Ethyne	74-86-2	26.04	-84.7
C2H2F3N	-CF2-NF- CH2-	1,2,2-trifluoro-aziridine	1514-44-9	97.04	-24.0
C2H2O	CH2CO	Ketene	463-51-4	42.04	-49.8
C2H3BF2	F2BCHCH2	(difluoro)vinylboran (Difluor)vinylboran (germ.)	358-95-2	75.85	-38.8
C2H3F3Si	F3Si-CH=CH2	trifluoro-vinyl-silane	421-24-9	112.13	-25.0
C2H4Si	HCCSiH3	Ethynylsilan	1066-27-9	56.14	-22.4
C2H5BF2	(C2H5)F2B	ethyl-difluor-borane Ethyl-difluor-boran (germ.)	430-41-1	77.87	-25.0
C2H5N	CH2=NCH3	methyl-methylen-amine	1761-67-7	43.07	-35.0
C2H6O	CH3OCH3	Dimethyl ether	115-10-6	46.07	-24.8
C2H6Si	H2CCHSiH3	vinyl-silane	7291-09-0	58.15	-22.8
C2H8Si	(CH3)2SiH2	Dimethylsilane	1111-74-6	60.17	-20.2
C2HCl	ClCCH	Chloroethyne	593-63-5	60.48	-30.2
C2HF		fluoroethyne//fluoro- acetylene	2713-09-9	44.03	-105.0
C2N2	NCCN	Ethanedinitrile	460-19-5	52.03	-21.2
C3F4	FCCCF3	tetrafluoropropyne//1,3,3,3- tetrafluoropropyne	20174-11-2	112.03	-50.0
C3F6O	cyclo-CF2- CF2-O-CF2-	hexafluoro-oxetane	425-82-1	166.02	-38.0
C3F6O	cyclo(-CF2-O- CF(CF3)-)	Trifluoro(trifluoromethyl)o xirane	428-59-1	166.02	-27.4
C3F6O	(CF3)2CO	1,1,1,3,3,3- Hexafluoropropanone	684-16-2	166.02	-27.3

C3F6O	CF3CF2C(O)F	pentafluoro-propionyl fluoride//perfluoropropionyl fluoride	422-61-7	166.02	-27.0
C3F6O	CF3OCFCF2	Trifluoromethyl trifluorovinyl ether	1187-93-5	166.02	-26.0
C3H4	CH3CCH	1-Propyne	74-99-7	40.06	-23.2
C3H6	- CH2CH2CH2-	Cyclopropane	75-19-4	42.08	-32.8
C3H8	CH3CH2CH3	Propane	74-98-6	44.10	-42.0
C3H9B	B(CH3)3	Trimethylborane	593-90-8	55.92	-20.2
C3HNO	OCCHCN	cyanoketene	4452-08-8	67.05	-34.0
C4H4	CH2=C=C=C H2	butatriene	2873-50-9	52.08	-78.0
C5F10NP	(C2F5)2PCN	Cyano-bispentafluorethylphosphin	35449-90-2	295.02	-78.0
C5H10F4Si	CHF2CF2Si(C H3)3	Trimethyl-1,1,2,2-tetrafluorethylsilan	4168-08-5	174.21	-72.0
CB2H8	CH3B2H5	methyl diborane Methyldiboran (germ.)	23777-55-1	41.70	-35.0
CBrFO	COBrF	carbonyl bromide fluoride	753-56-0	126.91	-20.6
CClF2NO	(F2C1)CN=O	chloro-difluoro-nitrosomethane//Chlor-difluoro-nitroso-methan	421-13-6	115.47	-35.0
CClF3O2	CF3-O-O-Cl	chloroperoxytrifluoromethane	32755-26-3	136.46	-22.0
CClFO	COClF	carbonylchlorid-fluorid Carbonylchloridfluorid (germ.)	353-49-1	82.46	-46.0
CF2N2	F2C(-N=N-)	3,3-difluoro-3#H!-diazirine	693-85-6	78.02	-91.3
CF2N2	F2C=N=N	difluoro diazomethane Difluordiazomethan (germ.)	814-73-3	78.02	-91.3
CF2O	F2CO	Carbonyl fluoride	353-50-4	66.01	-84.6
CF2O2	F2C(OO)	Difluordioxiran	96740-99-7	82.01	-85.0
CF3N3	(NF2)(F)C(- N=N-)	difluoro-(3-fluoro-3#H!-diazirin-3-yl)-amine	4823-43-2	111.03	-36.0
CF3N3	CF3-N-N-N	trifluoromethylazide Trifluormethylazid (germ.)	3802-95-7	110.03	-28.5
CF4N2	cyclo-(-NF- NF-CF2-)	tetrafluoro-diaziridine	17224-09-8	116.02	-35.0
CF4O2	CF3-O-O-F	Fluoroperoxytrifluormethan	34511-13-2	120.00	-69.4
CF4O2	F2C(OF)2	Bis(fluoroxy)difluormethan	16282-67-0	120.00	-64.0
CF5OP	OPF2CF3	Trifluormethylphosphonylfluorid	19162-94-8	153.98	-20.1
CFN		Cyanogen fluoride	1495-50-7	45.02	-46.2
CH2F3P	CF3PH2	Trifluormethylphosphane (germ.)	420-52-0	102.00	-26.5
CH2N2	H2CNN	Diazomethane	334-88-3	42.04	-23.2
CH2O		formaldehyde//Formalin	50-00-0	30.03	-21.0
CH3BF2	CH3BF2	(methyl)difluoroborane (Methyl)difluorboran	373-64-8	63.84	-62.3

		(germ.)			
CH3Cl	CH3Cl	Chloromethane	74-87-3	50.49	-24.2
CH3F2P	F2PCH3	methylphosphonous acid difluoride//difluoro-methyl-phosphine		84.01	-28.0
CH3F3OSi	F3Si-O-CH3	trifluoro-methoxy-silane	25711-11-9	116.11	-78.0
CH3FO	CH3-O-F	Methylhypofluorid	36336-08-0	50.03	-33.0
CH4	CH4	Methane	74-82-8	16.04	-161.5
CH6Si	CH3SiH3	Methylsilane	992-94-9	46.14	-56.9
CH7BrSi2	H3Si-CH2-SiH2Br	#Si!-bromo-#Si!,#Si!'-methanediyl-bis-silane	56962-86-8	155.14	-64.0
CH7ISi2	H3Si-CH2-SiH2I	#Si!-iodo-#Si!,#Si!'-methanediyl-bis-silane	56962-87-9	202.14	-49.0
CHF2NO2	F2CH-O-NO	Difluormethylnitrit	1493-06-7	97.02	-20.0
CHF3O	F3COH	trifluoromethanol	1493-11-4	86.01	-20.0
CHFO	HFCO	Formyl fluoride	1493-02-3	48.02	-26.5
CHNO	HOCN	Cyanic acid	420-05-3	43.03	-64.2
Cl2	Cl2	Chlorine	7782-50-5	70.91	-34.0
ClF	ClF	Chlorine fluoride	7790-89-8	54.45	-101.0
ClFO3		Chlorine trioxide fluoride	7616-94-6	102.45	-46.7
COSe	Se=C=O	carbon oxide selenide//Kohlenoxidselenid	1603-84-5	106.97	-21.7
F2	F2	Fluorine	7782-41-4	38.00	-188.2
F2H2Si	SiF2H2	Difluorosilane	13824-36-7	68.10	-77.8
F2O	OF2	Fluorine oxide	7783-41-7	54.00	-144.7
F2O2	FOOF	fluorine peroxide	7783-44-0	70.00	-57.0
F2O2S	SO2F2	Sulfuryl fluoride	2699-79-8	102.06	-55.3
F2S	SF2	sulphur difluoride	13814-25-0	70.06	-35.0
F3OP	POF3	Phosphorus trifluoride oxide	13478-20-1	103.97	-39.7
F3PS	PSF3	Phosphorus trifluoride sulfide	2404-52-6	120.03	-52.3
F4HP	PHF4	tetrafluorophosphorane	13659-66-0	107.98	-37.0
F4N2	F2NNF2	Tetrafluorohydrazine	10036-47-2	104.01	-74.2
F4S	SF4	Sulfur tetrafluoride	7783-60-0	108.05	-40.5
F6OSi2	SiF3OSiF3	hexafluoro disiloxane Hexafluordisiloxan (germ.)	14515-39-0	186.16	-23.0
FNO2	O2NF	Nitryl fluoride	10022-50-1	65.00	-72.3
H2	H2	Hydrogen	1333-74-0	2.02	-252.9
H2Se	H2Se	Hydrogen selenide	7783-07-5	80.98	-41.3
H3P	PH3	Phosphorus trihydride	7803-51-2	34.00	-87.8
H4Ge	GeH4	Germanium hydride	7782-65-2	76.62	-88.2
H4Si	SiH4	Silane	7803-62-5	32.12	-112.2
H4Sn	SnH4	Tin tetrahydride	2406-52-2	122.72	-51.8
O2	O2	Oxygen	7782-44-7	32.00	-183.0
O3	O3	Ozone	10028-15-6	48.00	-111.3
PSb	SbP	Antimony monophosphide	na	152.72	-52.3
PSi2	Si2P	Disilicon monophosphide	na	87.14	-52.3
Rn	Rn	Radon	10043-92-2	222.00	-61.7

Ar	Ar	Argon	7440-37-1	39.95	-185.9
BF3	BF3	Trifluoroborane	7637-07-2	67.81	-101.2
BrH	HBr	Hydrogen bromide	10035-10-6	80.91	-66.7
C2BrF5	CF3CF2Br	Bromopentafluoroethane	354-55-2	198.92	-21.0
C2ClF3	CFCl=CF2	Chlorotrifluoroethene	79-38-9	116.47	-28.4
C2F3N	CF3CN	Trifluoroacetonitrile	353-85-5	95.02	-68.8
C2F3NO	(CF3)NCO	trifluoromethyl isocyanate	460-49-1	111.02	-36.0
C2F4S	CF3C(S)F	trifluoromethyl thiocarbonyl fluoride Trifluormethylthiocarbonylfluorid (germ.)		132.08	-21.0
C2F5NO	CF3CF2NO	pentafluoro-nitroso-ethane//Pentafluor-nitroso-aethan	354-72-3	149.02	-45.7
C2F5NO	CF3C(O)NF2	(trifluoromethyl-carbonyl)-difluoro-amine	32822-49-4	149.02	-21.1
C2F6	CF3CF3	Hexafluoroethane	76-16-4	138.01	-78.2
C2F6NO	CF3N(O)CF3	Bis-trifluormethyl-nitroxid	2154-71-4	168.02	-20.0
C2F6O	CF3OCF3	bis-trifluoromethyl ether	1479-49-8	154.01	-59.0
C2F6Te	(CF3)2Te	bis(trifluoromethyl)tellurium	55642-42-7	265.61	-98.0
C2F6Te2	CF3TeTeCF3	bis(trifluoromethyl)ditelluride	1718-20-3	393.21	-53.0
C2F7N	CF3CF2NF2	N,N-Difluor-pentafluoraethylamin (germ.)	354-80-3	171.02	-38.0
C2F7N	(CF3)2NF	N-Fluor-bis(trifluormethyl)-amin (germ.)	359-62-6	171.02	-37.0
C2F7NO	CF3NFOCF3	N-Fluor-N-trifluormethoxy-perfluormethylamin (germ.)	4217-92-9	187.02	-25.0
C2FNO	FC(O)CN	fluoroformyl cyanide	683-55-6	73.03	-21.0
C2H2ClF	CH2CFC1	1-chloro-1-fluoro-ethene//1-Chlor-1-fluor-aethen//1-chloro-1-fluoroethylene	2317-91-1	80.49	-25.5
C2H2F2	CF2=CH2	1,1-Difluoroethene	75-38-7	64.03	-85.7
C2H2F2	CHF=CHF	#trans!-1,2-difluoro-ethene//#trans!-vinylene difluoride//(E)-1,2-difluoroethylene//(E)-1,2-difluoro-ethene//#trans!-vinylene fluoride	1630-78-0	64.03	-53.1
C2H2F2	FHC=CHF	1,2-difluoro-ethene//#cis!-vinylene difluoride//1,2-Difluor-aethen//vinylene fluoride	1691-13-0	64.03	-28.0
C2H2F2	CHF=CHF	#cis!-1,2-difluoro-ethene//#cis!-vinylene difluoride//(Z)-1,2-difluoroethylene//(Z)-1,2-difluoro-ethene//#cis!-vinylene fluoride	1630-77-9	64.03	-26.0
C2H2F4	CF3CH2F	1,1,1,2-Tetrafluoroethane	811-97-2	102.03	-26.1
C2H2F4	CF2HCF2H	1,1,2,2-Tetrafluoroethane	359-35-3	102.03	-23.0

C2H3F	CH ₂ =CHF	Fluoroethene	75-02-5	46.04	-72.2
C2H3F3	CF ₃ CH ₃	1,1,1-Trifluoroethane	420-46-2	84.04	-47.3
C2H3F3O	F ₃ COCH ₃	Ether, methyl trifluoromethyl	421-14-7	100.04	-24.0
C2H4	H ₂ CCH ₂	Ethene	74-85-1	28.05	-103.7
C2H4F2	CHF ₂ CH ₃	1,1-Difluoroethane	75-37-6	66.05	-24.0
C2H5F	CH ₃ CH ₂ F	Fluoroethane	353-36-6	48.06	-37.7
C2H6	CH ₃ CH ₃	Ethane	74-84-0	30.07	-88.6
C2H6BF	(CH ₃) ₂ BF	fluoro-dimethyl-borane	353-46-8	59.88	-44.0
C2H6F4OSi ₂	CH ₃ SiF ₂ OSiF ₂ CH ₃	Disiloxane, 1,1,3,3-tetrafluoro-1,3-dimethyl-	63089-45-2	178.23	-39.0
C2HF3	CF ₂ =CFH	Trifluoroethene	359-11-5	82.02	-51.0
C2HF3O	CF ₃ C(O)H	trifluoroacetaldehyde//Trifluor-acetaldehyd	75-90-1	98.02	-21.0
C2HF5	CF ₃ CF ₂ H	Pentafluoroethane	354-33-6	120.02	-48.1
C2HF5O	CF ₃ OCHF ₂	Difluoromethyl trifluoromethyl ether	3822-68-2	136.02	-35.3
C3BiF ₉	Bi(CF ₃) ₃	Tris(trifluoromethyl)bismuth	5863-80-9	416.00	-55.0
C3F4	F ₂ C=C=CF ₂	tetrafluoropropadiene//tetrafluoro-allene//1,1,3,3-tetrafluoro-1,2-propadiene	461-68-7	112.03	-38.0
C3F4	=CFCF ₂ CF=	tetrafluorocyclopropene	19721-29-0	112.03	-20.0
C3F5IO	CF ₃ CF ₂ C(O)I	Perfluoropropionyliodid	137741-03-8	273.93	-27.0
C3F5N	C ₂ F ₅ CN	pentafluoropropionitrile//pentafluoropropionitrile	422-04-8	145.03	-35.0
C3F6	cyclo - CF ₂ CF ₂ CF ₂ -	hexafluorocyclopropane//Hexafluorocyclopropan//freon-#C!216	931-91-9	150.02	-33.0
C3F6	CF ₃ CF=CF ₂	Hexafluoropropylene	116-15-4	150.02	-29.6
C3F6O ₂	cyclo-CF ₂ -O-CF ₂ -CF ₂ -O-	hexafluoro-[1,3]dioxolane	21297-65-4	182.02	-22.1
C3F8	CF ₃ CF ₂ CF ₃	Octafluoropropane	76-19-7	188.02	-36.7
C3F8O	CF ₃ CF ₂ OCF ₃	Perfluormethylethylether	665-16-7	204.02	-20.0
C3H2F2	F ₂ CCCH ₂	1,1-difluoropropadiene//allenyldene difluoride//1,1-difluoroallene	430-64-8	76.05	-21.0
C3H2F4	H ₂ CCFCF ₃	2,3,3,3-tetrafluoropropene//HFO-1234yf	754-12-1	114.04	-28.3
C3H2F4	CHF=CHCF ₃	trans HFO-1234ze		114.04	-19.0
C3H3F3	CH ₂ =CHCF ₃	3,3,3-Trifluoropropene	677-21-4	96.05	-25.0
C3H4	c-(CH=CH-CH ₂)	cyclopropene	2781-85-3	40.06	-36.0
C3H4	H ₂ CCCH ₂	Allene	463-49-0	40.06	-34.5
C3H4F2	CH ₃ CH=CF ₂	1,1-difluoropropene//propenyldene difluoride//1,1-Difluorpropen	430-63-7	78.06	-29.0

C3H4O		methylketene	6004-44-0	56.06	-23.0
C3H5F	CH2CFCH3	2-fluoropropene	1184-60-7	60.07	-24.0
C3H6	CH2CHCH3	1-Propene	115-07-1	42.08	-47.7
C3H7NO2		DL-2-aminopropanoic acid	302-72-7	89.09	-50.2
C3HF3	F3CCCH	3,3,3-trifluoro-propyne//3,3,3-Trifluoropropin//trifluoromethylethyne//3,3,3-trifluoro-1-propyne	661-54-1	94.04	-48.0
C3HF5	CF3CH=CF2	1,1,3,3,3-pentafluoropropene//1,1,3,3,3-Pentafluor-propen	690-27-7	132.03	-21.0
C3HF5	CF3-CF-CFH	1,2,3,3,3-pentafluoropropene	2252-83-7	132.03	-20.0
C4F6	CF3CCCF3	1,1,1,4,4,4-hexafluoro-2-butyne	692-50-2	162.03	-24.6
C4H2F4O2	CF2HC(O)C(O)CF2H	1,1,4,4-tetrafluoro-butane-2,3-dione		158.05	-81.0
C4H6N2O2				114.10	-33.0
CCIF3O	F3C-O-Cl	Trifluormethylhypochlorit	22082-78-6	120.46	-47.0
CCIF3O	ClF2C-OF	Chlor-difluor-methylhypofluorit	20614-17-9	120.46	-25.0
CCIF4N	CF3NFCl	N-Chlor-N-fluor-trifluormethylamin (germ.)	13880-72-3	137.46	-32.8
CCIF4N	ClCF2-NF2	Chlordifluordifluoraminoethan	13880-71-2	137.46	-28.0
CF2S	F2C=S	thiocarbonyl difluoride Thiocarbonyldifluorid (germ.)	420-32-6	82.07	-46.0
CF2Se	F2C=Se	selenocarbonyl difluoride	54393-39-4	128.97	-28.0
CF3I	CF3I	Trifluoroiodomethane	2314-97-8	195.91	-21.8
CF3N	CF2-N-F	N-Fluor-difluormethanimin (germ.)	338-66-9	83.01	-101.0
CF3NO	CF3N=O	trifluoro-nitroso-methane//Trifluor-nitroso-methan	334-99-6	99.01	-86.0
CF3NO	FC(O)NF2	difluoro-carbamoyl fluoride	2368-32-3	99.01	-52.0
CF3NO2	CF3NO2	trifluoro-nitro-methane//Trifluor-nitro-methan//fluoropicrin	335-02-4	115.01	-33.6
CF4	CF4	Tetrafluoromethane	75-73-0	88.00	-128.1
CF4N2	NF2CF=NF	Tetrafluorformamidin (germ.)	14362-70-0	116.02	-30.0
CF4N2O	(NF2)2CO	tetrafluorourea	10256-92-5	132.02	-20.0
CF4O		hypofluorous acid trifluoromethyl ester//Hypofluorigsaure-trifluormethylester//trifluoromethyl hypofluorite		104.00	-95.0
CF4O2S	CF3SO2F	trifluoromethanesulfonyl fluoride	335-05-7	152.07	-21.7
CF5N	CF3NF2	N,N-Difluor-	335-01-3	121.01	-75.0

		trifluormethylamin (germ.)			
CF5NO	CF3ONF2	Trifluormethoxydifluoramin	4217-93-0	137.01	-59.8
CF5NO2	F2NOCF2OF	(Difluoraminoxy)difluormethylhypofluorit	36781-60-9	153.01	-29.0
CF5NS	SF5CN	sulfurecyanide pentafluoride Schwefelcyanid-pentafluorid (germ.)	1512-13-6	153.08	-25.0
CF5P	CF3PF2	difluoro-trifluoromethylphosphine	1112-04-5	137.98	-43.0
CF6N2	F2NCF2NF2	Hexafluormethandiamin	4394-93-8	154.01	-37.0
CF6Si	CF3SiF3	perfluoro methyl silane Perfluormethylsilan (germ.)	335-06-8	154.09	-42.0
CF7P	CF3PF4	Trifluormethyl-tetrafluorphosphoran (germ.)	1184-81-2	175.97	-35.0
CH2F2	CH2F2	Difluoromethane	75-10-5	52.02	-51.7
CH2FI	CH2FI	Fluoriodomethane	373-53-5	159.93	-53.8
CH3F		fluoromethane//methyl fluoride//Fluor-methan//freon-41	593-53-3	34.03	-78.3
CH3F3Si	CF3SiH3	trifluoromethyl-silane" CF3SiH3	10112-11-5	100.12	-38.3
CH3F3Si	CH3SiF3	methyltrifluorosilane	373-74-0	100.12	-30.0
CH4F2Si	F2HSiCH3	difluoro-methyl-silane	420-34-8	82.12	-35.6
CH5FSi	CH3SiH2F	fluoro-methyl-silane	753-44-6	64.13	-44.0
CH6Ge	H3GeCH3	methylgermane	1449-65-6	90.65	-23.0
CHF2N	F2C=NH	Difluorformimin	2712-98-3	65.02	-22.0
CHF3	CHF3	Trifluoromethane	75-46-7	70.01	-82.1
CHF3S	CF3SH	trifluoromethane thiol Trifluormethanthiol (germ.)	1493-15-8	102.08	-36.7
CHF4N	CF2H-NF2	N,N,1,1-Tetrafluormethylamin	24708-53-0	103.02	-43.0
Cl2F2Si	SiF2Cl2	difluoro dichlorosilane Difluordichlorsilan (germ.)	18356-71-3	136.99	-31.8
ClF2HSi	SiF2HCl	difluoro chlorosilane Difluorchlorsilan (germ.)	80003-43-6	102.56	-50.0
ClF2P	PF2Cl	Phosphorus chloride difluoride	14335-40-1	104.42	-47.3
ClF3Si	SiClF3	Chlorotrifluorosilane	14049-36-6	120.53	-70.2
ClH	HCl	Hydrogen chloride	7647-01-0	36.46	-85.0
ClH3Si	SiH3Cl	Chlorosilane	13465-78-6	66.56	-30.3
CO	CO	Carbon monoxide	630-08-0	28.01	-191.5
CO2	CO2	Carbon dioxide	124-38-9	44.01	-78.4
COS	OCS	Carbonyl sulfide	463-58-1	60.07	-50.3
F2HN	NHF2	Difluoramine	10405-27-3	53.01	-23.2
F2N2	FNNF	trans-Difluorodiazine	13776-62-0	66.01	-111.5
F2N2	FNNF	cis-Difluorodiazine	13812-43-6	66.01	-105.8

F2OS	F2SO	Thionyl fluoride	7783-42-8	86.06	-43.8
F3HSi	SiHF3	Trifluorosilane	13465-71-9	86.09	-95.2
F3N	NF3	Nitrogen trifluoride	7783-54-2	71.00	-129.1
F3NO	NOF3	Trifluoramine oxide	13847-65-9	87.00	-87.5
F3NS	NSF3	thiazyl trifluoride	15930-75-3	103.07	-27.1
F3P	PF3	Phosphorus trifluoride	7783-55-3	87.97	-101.5
F4Ge	GeF4	Germanium(IV) fluoride	7783-58-6	148.58	-36.5
F4Si	SiF4	Tetrafluorosilane	7783-61-1	104.08	-86.0
F5P	PF5	Phosphorus pentafluoride	7647-19-0	125.97	-84.5
F6Se	SeF6	Selenium hexafluoride	7783-79-1	192.95	-46.5
F6Te	TeF6	Tellurium hexafluoride	7783-80-4	241.59	-38.8
FH3Si	SiH3F	fluorosilane	13537-33-2	50.11	-98.0
FNO		Nitrosyl fluoride	7789-25-5	49.00	-59.9
FNO3		Fluorine nitrate	7789-26-6	81.00	-46.2
H2S	H2S	Hydrogen sulfide	7783-06-4	34.08	-59.5
H3N	NH3	Ammonia	7664-41-7	17.03	-33.3
He	He	Helium	7440-59-7	4.00	-268.9
HI	HI	Hydrogen iodide	10034-85-2	127.91	-35.6
Kr	Kr	Krypton	7439-90-9	83.80	-153.4
N2	N2	Nitrogen	7727-37-9	28.01	-195.8
N2O	NNO	dinitrogen oxide	10024-97-2	44.01	-88.5
Ne	Ne	Neon	7440-01-9	20.18	-246.1
NO	NO	Nitrogen oxide	10102-43-9	30.01	-151.8
Xe	Xe	Xenon	7440-63-3	131.29	-108.1

The preferred dielectric compounds are selected from the group consisting of those set forth in Table 2 below:

5

TABLE 2

Dielectric Compound	Structure	Name	CAS	MW	MY BP(oC)
Ar	Ar	Argon	7440-37-1	39.95	-185.9
BF3	BF3	Trifluoroborane	7637-07-2	67.81	-101.2
BrH	HBr	Hydrogen bromide	10035-10-6	80.91	-66.7
C2BrF5	CF3CF2Br	Bromopentafluoroethane	354-55-2	198.92	-21.0
C2ClF3	CFCl=CF2	Chlorotrifluoroethene	79-38-9	116.47	-28.4
C2F3N	CF3CN	Trifluoroacetonitrile	353-85-5	95.02	-68.8
C2F3NO	(CF3)NCO	trifluoromethyl isocyanate	460-49-1	111.02	-36.0
C2F4S	CF3C(S)F	trifluoromethyl thiocarbonyl fluoride Trifluormethylthiocarbonylfluorid (germ.)		132.08	-21.0
C2F5NO	CF3CF2NO	pentafluoro-nitroso-ethane//Pentafluor-nitroso-aethan	354-72-3	149.02	-45.7

C2F5NO	CF3C(O)NF2	(trifluoromethyl-carbonyl)-difluoro-amine	32822-49-4	149.02	-21.1
C2F6	CF3CF3	Hexafluoroethane	76-16-4	138.01	-78.2
C2F6NO	CF3N(O)CF3	Bis-trifluoromethyl-nitroxid	2154-71-4	168.02	-20.0
C2F6O	CF3OCF3	bis-trifluoromethyl ether	1479-49-8	154.01	-59.0
C2F6Te	(CF3)2Te	bis(trifluoromethyl)tellurium	55642-42-7	265.61	-98.0
C2F6Te2	CF3TeTeCF3	bis(trifluoromethyl) ditelluride	1718-20-3	393.21	-53.0
C2F7N	CF3CF2NF2	N,N-Difluor-pentafluoraethylamin (germ.)	354-80-3	171.02	-38.0
C2F7N	(CF3)2NF	N-Fluor-bis(trifluormethyl)-amin (germ.)	359-62-6	171.02	-37.0
C2F7NO	CF3NFOCF3	N-Fluor-N-trifluormethoxy-perfluormethylamin (germ.)	4217-92-9	187.02	-25.0
C2FNO	FC(O)CN	fluoroformyl cyanide	683-55-6	73.03	-21.0
C2H2CIF	CH2CFC1	1-chloro-1-fluoro-ethene//1-Chlor-1-fluor-aethen//1-chloro-1-fluoroethylene	2317-91-1	80.49	-25.5
C2H2F2	CF2=CH2	1,1-Difluoroethene	75-38-7	64.03	-85.7
C2H2F2	CHF=CHF	#trans!-1,2-difluoro-ethene//#trans!-vinylene difluoride//(E)-1,2-difluoroethylene//(E)-1,2-difluoro-ethene//#trans!-vinylene fluoride	1630-78-0	64.03	-53.1
C2H2F2	FHC=CHF	1,2-difluoro-ethene//#cis!-vinylene difluoride//1,2-Difluor-aethen//vinylene fluoride	1691-13-0	64.03	-28.0
C2H2F2	CHF=CHF	#cis!-1,2-difluoro-ethene//#cis!-vinylene difluoride//(Z)-1,2-difluoroethylene//(Z)-1,2-difluoro-ethene//#cis!-vinylene fluoride	1630-77-9	64.03	-26.0
C2H2F4	CF3CH2F	1,1,1,2-Tetrafluoroethane	811-97-2	102.03	-26.1
C2H2F4	CF2HCF2H	1,1,2,2-Tetrafluoroethane	359-35-3	102.03	-23.0
C2H3F	CH2=CHF	Fluoroethene	75-02-5	46.04	-72.2
C2H3F3	CF3CH3	1,1,1-Trifluoroethane	420-46-2	84.04	-47.3
C2H3F3O	F3COCH3	Ether, methyl trifluoromethyl	421-14-7	100.04	-24.0
C2H4	H2CCH2	Ethene	74-85-1	28.05	-103.7
C2H4F2	CHF2CH3	1,1-Difluoroethane	75-37-6	66.05	-24.0
C2H5F	CH3CH2F	Fluoroethane	353-36-6	48.06	-37.7
C2H6	CH3CH3	Ethane	74-84-0	30.07	-88.6
C2H6BF	(CH3)2BF	fluoro-dimethyl-borane	353-46-8	59.88	-44.0
C2H6F4OSi2	CH3SiF2OSiF2CH3	Disiloxane, 1,1,3,3-tetrafluoro-1,3-dimethyl-	63089-45-2	178.23	-39.0
C2HF3	CF2=CFH	Trifluoroethene	359-11-5	82.02	-51.0

C2HF3O	CF3C(O)H	trifluoroacetaldehyde//Trifluor-acetaldehyd	75-90-1	98.02	-21.0
C2HF5	CF3CF2H	Pentafluoroethane	354-33-6	120.02	-48.1
C2HF5O	CF3OCHF2	Difluoromethyl trifluoromethyl ether	3822-68-2	136.02	-35.3
C3BiF9	Bi(CF3)3	Tris(trifluoromethyl)bismuth	5863-80-9	416.00	-55.0
C3F4	F2C=C=CF2	tetrafluoropropadiene//tetrafluoro-allene//1,1,3,3-tetrafluoro-1,2-propadiene	461-68-7	112.03	-38.0
C3F4	=CFCF2CF=	tetrafluorocyclopropene	19721-29-0	112.03	-20.0
C3F5IO	CF3CF2C(O)I	Perfluoropropionyl iodid	137741-03-8	273.93	-27.0
C3F5N	C2F5CN	pentafluoropropionitrile//pentafluoropropionitrile	422-04-8	145.03	-35.0
C3F6	cyclo - CF2CF2CF2-	hexafluorocyclopropane//Hexafluorocyclopropan//freon-#C!216	931-91-9	150.02	-33.0
C3F6	CF3CF=CF2	Hexafluoropropylene	116-15-4	150.02	-29.6
C3F6O2	cyclo-CF2-O-CF2-CF2-O-	hexafluoro-[1,3]dioxolane	21297-65-4	182.02	-22.1
C3F8	CF3CF2CF3	Octafluoropropane	76-19-7	188.02	-36.7
C3F8O	CF3CF2OCF3	Perfluormethylethylether	665-16-7	204.02	-20.0
C3H2F2	F2CCCH2	1,1-difluoropropadiene//allenylidene difluoride//1,1-difluoroallene	430-64-8	76.05	-21.0
C3H2F4	H2CCFCF3	2,3,3,3-tetrafluoropropene//HFO-1234yf	754-12-1	114.04	-28.3
C3H2F4	CHF=CHCF3	trans HFO-1234ze		114.04	-19.0
C3H3F3	CH2=CHCF3	3,3,3-Trifluoropropene	677-21-4	96.05	-25.0
C3H4	c-(CH=CH-CH2)	cyclopropene	2781-85-3	40.06	-36.0
C3H4	H2CCCH2	Allene	463-49-0	40.06	-34.5
C3H4F2	CH3CH=CF2	1,1-difluoropropene//propenylidene difluoride//1,1-Difluorpropen	430-63-7	78.06	-29.0
C3H4O		methylketene	6004-44-0	56.06	-23.0
C3H5F	CH2CFCH3	2-fluoropropene	1184-60-7	60.07	-24.0
C3H6	CH2CHCH3	1-Propene	115-07-1	42.08	-47.7
C3H7NO2		DL-2-aminopropanoic acid	302-72-7	89.09	-50.2
C3HF3	F3CCCH	3,3,3-trifluoropropyne//3,3,3-Trifluorpropin//trifluoromethylethyne//3,3,3-trifluoro-1-propyne	661-54-1	94.04	-48.0
C3HF5	CF3CH=CF2	1,1,3,3,3-pentafluoropropene//1,1,3,3,3-Pentafluorpropen	690-27-7	132.03	-21.0
C3HF5	CF3-CF-CFH	1,2,3,3,3-pentafluoro-	2252-83-7	132.03	-20.0

		propene			
C4F6	CF3CCCF3	1,1,1,4,4,4-hexafluoro-2-butyne	692-50-2	162.03	-24.6
C4H2F4O2	CF2HC(O)C(O)CF2H	1,1,4,4-tetrafluoro-butane-2,3-dione		158.05	-81.0
C4H6N2O2				114.10	-33.0
CCIF3O	F3C-O-Cl	Trifluormethylhypochlorit	22082-78-6	120.46	-47.0
CCIF3O	ClF2C-OF	Chlor-difluor-methylhypofluorit	20614-17-9	120.46	-25.0
CCIF4N	CF3NFC1	N-Chlor-N-fluor-trifluormethylamin (germ.)	13880-72-3	137.46	-32.8
CCIF4N	ClCF2-NF2	Chlordifluordifluoraminoethan	13880-71-2	137.46	-28.0
CF2S	F2C=S	thiocarbonyl difluoride Thiocarbonyldifluorid (germ.)	420-32-6	82.07	-46.0
CF2Se	F2C=Se	selenocarbonyl difluoride	54393-39-4	128.97	-28.0
CF3I	CF3I	Trifluoroiodomethane	2314-97-8	195.91	-21.8
CF3N	CF2-N-F	N-Fluor-difluormethanimin (germ.)	338-66-9	83.01	-101.0
CF3NO	CF3N=O	trifluoro-nitroso-methane//Trifluor-nitroso-methan	334-99-6	99.01	-86.0
CF3NO	FC(O)NF2	difluoro-carbamoyl fluoride	2368-32-3	99.01	-52.0
CF3NO2	CF3NO2	trifluoro-nitro-methane//Trifluor-nitro-methan//fluoropicrin	335-02-4	115.01	-33.6
CF4	CF4	Tetrafluoromethane	75-73-0	88.00	-128.1
CF4N2	NF2CF=NF	Tetrafluorformamidin (germ.)	14362-70-0	116.02	-30.0
CF4N2O	(NF2)2CO	tetrafluorourea	10256-92-5	132.02	-20.0
CF4O		hypo-fluorous acid trifluoromethyl ester//Hypo-fluorigsaure-trifluoromethylester//trifluoromethyl hypofluorite		104.00	-95.0
CF4O2S	CF3SO2F	trifluoromethanesulfonyl fluoride	335-05-7	152.07	-21.7
CF5N	CF3NF2	N,N-Difluor-trifluormethylamin (germ.)	335-01-3	121.01	-75.0
CF5NO	CF3ONF2	Trifluormethyloxydifluoramin	4217-93-0	137.01	-59.8
CF5NO2	F2NOCF2OF	(Difluoraminoxyl)difluormethylhypofluorit	36781-60-9	153.01	-29.0
CF5NS	SF5CN	sulfurcyanide pentafluoride Schwefelcyanid-pentafluorid (germ.)	1512-13-6	153.08	-25.0
CF5P	CF3PF2	difluoro-trifluoromethylphosphine	1112-04-5	137.98	-43.0
CF6N2	F2NCF2NF2	Hexafluormethandiamin	4394-93-8	154.01	-37.0
CF6Si	CF3SiF3	perfluoro methyl silane Perfluormethylsilan	335-06-8	154.09	-42.0

		(germ.)			
CF7P	CF3PF4	Trifluoromethyl-tetrafluorophosphan (germ.)	1184-81-2	175.97	-35.0
CH2F2	CH2F2	Difluoromethane	75-10-5	52.02	-51.7
CH2FI	CH2FI	Fluoroiodomethane	373-53-5	159.93	-53.8
CH3F		fluoromethane//methyl fluoride//Fluor-methan//freon-41	593-53-3	34.03	-78.3
CH3F3Si	CF3SiH3	trifluoromethyl-silane" CF3SiH3	10112-11-5	100.12	-38.3
CH3F3Si	CH3SiF3	methyltrifluorosilane	373-74-0	100.12	-30.0
CH4F2Si	F2HSiCH3	difluoro-methyl-silane	420-34-8	82.12	-35.6
CH5FSi	CH3SiH2F	fluoro-methyl-silane	753-44-6	64.13	-44.0
CH6Ge	H3GeCH3	methylgermane	1449-65-6	90.65	-23.0
CHF2N	F2C=NH	Difluorformimin	2712-98-3	65.02	-22.0
CHF3	CHF3	Trifluoromethane	75-46-7	70.01	-82.1
CHF3S	CF3SH	trifluoromethane thiol Trifluormethanthiol (germ.)	1493-15-8	102.08	-36.7
CHF4N	CF2H-NF2	N,N,1,1-Tetrafluormethylamin	24708-53-0	103.02	-43.0
Cl2F2Si	SiF2Cl2	difluoro dichlorosilane Difluordichlorsilan (germ.)	18356-71-3	136.99	-31.8
ClF2HSi	SiF2HCl	difluoro chlorosilane Difluorchlorsilan (germ.)	80003-43-6	102.56	-50.0
ClF2P	PF2Cl	Phosphorus chloride difluoride	14335-40-1	104.42	-47.3
ClF3Si	SiClF3	Chlorotrifluorosilane	14049-36-6	120.53	-70.2
ClH	HCl	Hydrogen chloride	7647-01-0	36.46	-85.0
ClH3Si	SiH3Cl	Chlorosilane	13465-78-6	66.56	-30.3
CO	CO	Carbon monoxide	630-08-0	28.01	-191.5
CO2	CO2	Carbon dioxide	124-38-9	44.01	-78.4
COS	OCS	Carbonyl sulfide	463-58-1	60.07	-50.3
F2HN	NHF2	Difluoramine	10405-27-3	53.01	-23.2
F2N2	FNNF	trans-Difluorodiazine	13776-62-0	66.01	-111.5
F2N2	FNNF	cis-Difluorodiazine	13812-43-6	66.01	-105.8
F2OS	F2SO	Thionyl fluoride	7783-42-8	86.06	-43.8
F3HSi	SiHF3	Trifluorosilane	13465-71-9	86.09	-95.2
F3N	NF3	Nitrogen trifluoride	7783-54-2	71.00	-129.1
F3NO	NOF3	Trifluoramine oxide	13847-65-9	87.00	-87.5
F3NS	NSF3	thiazyl trifluoride	15930-75-3	103.07	-27.1
F3P	PF3	Phosphorus trifluoride	7783-55-3	87.97	-101.5
F4Ge	GeF4	Germanium(IV) fluoride	7783-58-6	148.58	-36.5
F4Si	SiF4	Tetrafluorosilane	7783-61-1	104.08	-86.0
F5P	PF5	Phosphorus pentafluoride	7647-19-0	125.97	-84.5
F6Se	SeF6	Selenium hexafluoride	7783-79-1	192.95	-46.5
F6Te	TeF6	Tellurium hexafluoride	7783-80-4	241.59	-38.8
FH3Si	SiH3F	fluorosilane	13537-33-2	50.11	-98.0
FNO		Nitrosyl fluoride	7789-25-5	49.00	-59.9

FNO3		Fluorine nitrate	7789-26-6	81.00	-46.2
H2S	H2S	Hydrogen sulfide	7783-06-4	34.08	-59.5
H3N	NH3	Ammonia	7664-41-7	17.03	-33.3
He	He	Helium	7440-59-7	4.00	-268.9
HI	HI	Hydrogen iodide	10034-85-2	127.91	-35.6
Kr	Kr	Krypton	7439-90-9	83.80	-153.4
N2	N2	Nitrogen	7727-37-9	28.01	-195.8
N2O	NON	Nitrous oxide	10024-97-2	44.01	-88.5
Ne	Ne	Neon	7440-01-9	20.18	-246.1
NO	NO	Nitrogen oxide	10102-43-9	30.01	-151.8
Xe	Xe	Xenon	7440-63-3	131.29	-108.1

The aforementioned dielectric compounds may be used in pure form, but can also be used as part of an azeotrope, or a mixture with an appropriate second gas, i.e., nitrogen, CO₂ or N₂O.

Particularly preferred non-electrical properties for dielectric gases according to the present disclosure, include:

- Non-liquefying, e.g., T_{boil} less than -20°C
- Chemically stable – decomposition temperature must be higher than hot spot temperature in equipment, e.g., T_{dec} = 200°C, and gas should not decompose in partial discharge spark (approximately 1000°K)
- Low environmental impact, i.e., little to no destruction of ozone layer ODP = 0; and low global warming impact GWP less than SF₆
- Acceptably low toxicity of gas and discharge byproducts

Electrical equipment property requirements for dielectric gases according to the present disclosure, include:

- Insulation specific criteria include a critical field of E_{cr}, and no conducting decomposition products should be generated by discharge
- Switching specific criteria include high critical field of E_{cr}, arcing stability, i.e., a gas must recombine to original molecular structure after being decomposed in switching arc (Gibbs free energy of reaction is < 0)

- Specific thermal interruption performance, i.e., must be able to interrupt current flow at ac current zero
- Arc erosion product from equipment and gas must not form conduction deposits
- 5 • Low velocity of sound

Example 1

10 Measurements of the dielectric strength of potential alternatives were determined using ASTM D2477 or obtained from literature. These measurements were performed at 1 atmosphere pressure across a 0.1 inch gap and at ambient temperature.

15 In the intended applications, the gas will not be at 1 atmosphere pressure but at a higher pressure. In this example 5 atmospheres pressure is used as a maximum pressure. If the gas liquefies at a lower pressure than that pressure was used. These gases have higher dielectric strengths and break down voltages than air. Using 5 atmospheres (73.5 psia) pressure as the upper pressure (rating of the equipment).

20

Gas	Dielectric strength	Pressure	Breakdown voltage at maximum pressure
	kV/0.1 inch gap	(psia)	(kV /0.1 inch gap)
Air	4.75	73.5	23.75
R143a	5.8	73.5	29
R152a	5.9	73.5	29.5
R125	6.4	73.5	32
R134a	6.6	73.5	33

R22	7.2	73.5	39.9
R124	10.4	55.5	39.3
SF6	14.0	73.5	70
C318	16.0	45.3	49.3
R115	16.0	73.6	80
R114	17.0	31.1	36

Example 2

5 The dielectric strength of additional gases is measure at 1 atmosphere
and at the maximum system pressure. Their breakdown voltages are found to be
greater then air, which allows smaller gaps and therefore smaller equipment then
would be need if air was used. Here the measurements were performed on
CTFE (Chlorotrifluoroethylene), HCl (hydrogen chloride) and SiF4 (silicon
10 tetrafluoride).

 Having described the invention in detail by reference to the preferred
embodiments and specific examples thereof, it will be apparent that
modifications and variations are possible without departing from the spirit and
15 scope of the disclosure and claims.

What is claimed is:

1. A dielectric gaseous compound which exhibits the following properties:
 a boiling point in the range between about -20°C to about -273°C;
 low non-ozone depleting;
 5 a GWP less than about 22,200;
 chemical stability, as measured by a negative standard enthalpy of
 formation ($dH_f < 0$);
 a toxicity level such that when the dielectric gas leaks, the effective
 diluted concentration does not exceed its PEL in the working environment; and
 10 a dielectric strength greater than air.

2. The dielectric gaseous compound according to claim 1, wherein said
 dielectric gaseous compound is at least one compound selected from the group
 consisting of:

Arsenic pentafluoride
 Arsine
 Diboron tetrafluoride
 Diborane
 Perchloric acid, 2-chloro-1,1,2,2-tetrafluoroethyl ester (9CI)
 Perchloric acid, 1,2,2-trichloro-1,2-difluoroethyl ester
 Trifluoroacetyl chloride
 trifluoromethylisocyanide (CF₃-NC)
 trifluoromethyl isocyanide
 trifluoro-nitroso-ethene//Trifluor-nitroso-aethen
 Tetrafluoroethene
 3,3,4,4-tetrafluoro-3,4-dihydro-[1,2]diazete
 (Difluoramino)difluoroacetonitril
 Tetrafluorooxirane
 Trifluoroacetyl fluoride
 Perfluoromethylfluorformiat
 trifluoro-acetyl hypofluorite
 perfluoro-2-aza-1-propene
 Perfluor-2-aza-1-propen (germ.)
 N-Fluor-tetrafluor-1-aethanimin (germ.)
 3,3-difluoro-2-trifluoromethyl-oxaziridine
 bis-trifluoromethyl-diazene//hexafluoro-#cis!-azomethane
 Fluoroxypentafluoroethane

bis-trifluoromethyl peroxide
1,1-Bis(fluoroxy)tetrafluoroethane
Hexafluorodimethyl sulfide
3-fluoro-3#H!-diazirine-3-carbonitrile
Ethyne
1,2,2-trifluoro-aziridine
Ketene
(difluoro)vinylborane
(Difluor)vinylborane (germ.)
trifluoro-vinyl-silane
Ethinylsilane
ethyl-difluor-borane
Ethyl-difluor-borane (germ.)
methyl-methylene-amine
Dimethyl ether
vinyl-silane
Dimethylsilane
Chloroethyne
fluoroethyne//fluoro-acetylene
Ethanedinitrile
tetrafluoropropyne//1,3,3,3-tetrafluoropropyne
hexafluoro-oxetane
Trifluoro(trifluoromethyl)oxirane
1,1,1,3,3,3-Hexafluoropropanone
pentafluoro-propionyl fluoride//perfluoropropionyl fluoride
Trifluoromethyl trifluorovinyl ether
1-Propyne
Cyclopropane
Propane
Trimethylborane
cyanoketene
butatriene
Cyano-bis(pentafluoroethyl)-phosphine
Trimethyl-1,1,2,2-tetrafluoroethylsilane
methyl diborane
Methyldiborane (germ.)
carbonyl bromide fluoride
chloro-difluoro-nitroso-methane//Chlor-difluor-nitroso-methane
chloroperoxytrifluoromethane
carbonylchloride-fluoride
Carbonylchloridefluoride (germ.)
3,3-difluoro-3#H!-diazirine
difluoro diazomethane
Difluordiazomethane (germ.)
Carbonyl fluoride

Difluordioxiran
 difluoro-(3-fluoro-3H-diazirin-3-yl)-amine
 trifluoromethylazide
 Trifluormethylazid (germ.)
 tetrafluoro-diaziridine
 Fluorperoxytrifluormethan
 Bis(fluoroxy)difluormethan
 Trifluormethyl-phosphonylfluorid
 Cyanogen fluoride
 Trifluormethylphosphane (germ.)
 Diazomethane
 formaldehyde/Formalin
 (methyl)difluoroborane
 (Methyl)difluorboran (germ.)
 Chloromethane
 methylphosphonous acid difluoride//difluoro-methyl-phosphine
 trifluoro-methoxy-silane
 Methylhypofluorid
 Methane
 Methylsilane
 #Si'-bromo-#Si',#Si'-methanediyl-bis-silane
 #Si'-iodo-#Si',#Si'-methanediyl-bis-silane
 Difluormethylnitrit
 trifluoromethanol
 Formyl fluoride
 Cyanic acid
 Chlorine
 Chlorine fluoride
 Chlorine trioxide fluoride
 carbon oxide selenide//Kohlenoxidselenid
 Fluorine
 Difluorosilane
 Fluorine oxide
 fluorine peroxide
 Sulfuryl fluoride
 sulphur difluoride
 Phosphorus trifluoride oxide
 Phosphorus trifluoride sulfide
 tetrafluorophosphorane
 Tetrafluorohydrazine
 Sulfur tetrafluoride
 hexafluoro disiloxane
 Hexafluordisiloxan (germ.)
 Nitryl fluoride
 Hydrogen

Hydrogen selenide
 Phosphorus trihydride
 Germanium hydride
 Silane
 Tin tetrahydride
 Oxygen
 Ozone
 Antimony monophosphide
 Disilicon monophosphide
 Radon
 Argon
 Trifluoroborane
 Hydrogen bromide
 Bromopentafluoroethane
 Chlorotrifluoroethene
 Trifluoroacetonitrile
 trifluoromethyl isocyanate
 trifluoromethyl thiocarbonyl fluoride
 Trifluormethylthiocarbonylfluorid (germ.)
 pentafluoro-nitroso-ethane//Pentafluor-nitroso-aethan
 (trifluoromethyl-carbonyl)-difluoro-amine
 Hexafluoroethane
 Bis-trifluormethyl-nitroxid
 bis-trifluoromethyl ether
 bis(trifluoromethyl)tellurium
 bis(trifluoromethyl) ditelluride
 N,N-Difluor-pentafluoraethylamin (germ.)
 N-Fluor-bis(trifluormethyl)-amin (germ.)
 N-Fluor-N-trifluormethoxy-perfluormethylamin (germ.)
 fluoroformyl cyanide
 1-chloro-1-fluoro-ethene//1-Chlor-1-fluor-aethen//1-chloro-1-fluoroethylene
 1,1-Difluoroethene
 #trans!-1,2-difluoro-ethene//#trans!-vinylene difluoride//(E)-1,2-
 difluoroethylene//(E)-1,2-difluoro-ethene//#trans!-vinylene fluoride
 1,2-difluoro-ethene//#cis!-vinylene difluoride//1,2-Difluor-aethen//vinylene
 fluoride
 #cis!-1,2-difluoro-ethene//#cis!-vinylene difluoride//(Z)-1,2-
 difluoroethylene//(Z)-1,2-difluoro-ethene//#cis!-vinylene fluoride
 1,1,1,2-Tetrafluoroethane
 1,1,2,2-Tetrafluoroethane
 Fluoroethene
 1,1,1-Trifluoroethane
 Ether, methyl trifluoromethyl
 Ethene
 1,1-Difluoroethane

Fluoroethane
 Ethane
 fluoro-dimethyl-borane
 Disiloxane, 1,1,3,3-tetrafluoro-1,3-dimethyl-
 Trifluoroethene
 trifluoroacetaldehyde//Trifluor-acetaldehyd
 Pentafluoroethane
 Difluoromethyl trifluoromethyl ether
 Tris(trifluoromethyl)bismuth
 tetrafluoropropadiene//tetrafluoro-allene//1,1,3,3-tetrafluoro-1,2-propadiene
 tetrafluorocyclopropene
 Perfluoropropionylidid
 pentafluoro-propionitrile//pentafluoropropionitrile
 hexafluoro-cyclopropane//Hexafluor-cyclopropan//freon-#C!216
 Hexafluoropropylene
 hexafluoro-[1,3]dioxolane
 Octafluoropropane
 Perfluormethylethylether
 1,1-difluoro-propadiene//allenyldiene difluoride//1,1-difluoro-allene
 2,3,3,3-tetrafluoro-propene//HFO-1234yf
 trans HFO-1234ze
 3,3,3-Trifluoropropene
 cyclopropene
 Allene
 1,1-difluoro-propene//propenyldiene difluoride//1,1-Difluor-propen
 methylketene
 2-fluoropropene
 1-Propene
 DL-2-aminopropanoic acid
 3,3,3-trifluoro-propyne//3,3,3-Trifluor-propin//trifluoromethyl-ethyne//3,3,3-
 trifluoro-1-propyne
 1,1,3,3,3-pentafluoro-propene//1,1,3,3,3-Pentafluor-propen
 1,2,3,3,3-pentafluoro-propene
 1,1,1,4,4,4-hexafluoro-2-butyne
 1,1,4,4-tetrafluoro-butane-2,3-dione

 Trifluormethylhypochlorit
 Chlor-difluor-methyl-hypofluorit
 N-Chlor-N-fluor-trifluormethylamin (germ.)
 Chlordifluordifluoraminoethan
 thiocarbonyl difluoride
 Thiocarbonyldifluorid (germ.)
 selenocarbonyl difluoride
 Trifluoroiodomethane
 N-Fluor-difluormethanimin (germ.)

trifluoro-nitroso-methane//Trifluor-nitroso-methan
difluoro-carbamoyl fluoride
trifluoro-nitro-methane//Trifluor-nitro-methan//fluoropicrin
Tetrafluoromethane
Tetrafluorformamidin (germ.)
tetrafluorourea
hypofluorous acid trifluoromethyl ester//Hypofluorigsaecure-
trifluormethylester//trifluoromethyl hypofluorite
trifluoromethanesulfonyl fluoride
N,N-Difluor-trifluormethylamin (germ.)
Trifluormethyloxydifluoramin
(Difluoraminoxyl)difluormethylhypofluorit
sulfurcyanide pentafluoride
Schwefelcyanid-pentafluorid (germ.)
difluoro-trifluoromethyl-phosphine
Hexafluormethandiamin
perfluoro methyl silane
Perfluormethylsilan (germ.)
Trifluormethyl-tetrafluorphosphoran (germ.)
Difluoromethane
Fluoriodomethane
fluoromethane//methyl fluoride//Fluor-methan//freon-41
trifluoromethyl-silane" CF₃SiH₃
methyltrifluorosilane
difluoro-methyl-silane
fluoro-methyl-silane
methylgermane
Difluorformimin
Trifluoromethane
trifluoromethane thiol
Trifluormethanthiol (germ.)
N,N,1,1-Tetrafluormethylamin
difluoro dichlorosilane
Difluordichlorsilan (germ.)
difluoro chlorosilane
Difluorchlorsilan (germ.)
Phosphorus chloride difluoride
Chlorotrifluorosilane
Hydrogen chloride
Chlorosilane
Carbon monoxide
Carbon dioxide
Carbonyl sulfide
Difluoramine
trans-Difluorodiazine

cis-Difluorodiazine
Thionyl fluoride
Trifluorosilane
Nitrogen trifluoride
Trifluoramine oxide
thiazyl trifluoride
Phosphorus trifluoride
Germanium(IV) fluoride
Tetrafluorosilane
Phosphorus pentafluoride
Selenium hexafluoride
Tellurium hexafluoride
fluorosilane
Nitrosyl fluoride
Fluorine nitrate
Hydrogen sulfide
Ammonia
Helium
Hydrogen iodide
Krypton
Nitrogen
dinitrogen oxide
Neon
Nitrogen oxide; and
Xenon

3. The dielectric gaseous compound according to claim 2, wherein said dielectric gaseous compound is at least one compound selected from the group
- 5 consisting of:

Argon
Trifluoroborane
Hydrogen bromide
Bromopentafluoroethane
Chlorotrifluoroethene
Trifluoroacetonitrile
trifluoromethyl isocyanate
trifluoromethyl thiocarbonyl fluoride
Trifluormethylthiocarbonylfluorid (germ.)
pentafluoro-nitroso-ethane//Pentafluor-nitroso-aethan
(trifluoromethyl-carbonyl)-difluoro-amine
Hexafluoroethane

Bis-trifluormethyl-nitroxid
 bis-trifluoromethyl ether
 bis(trifluoromethyl)tellurium
 bis(trifluoromethyl) ditelluride
 N,N-Difluor-pentafluoraethylamin (germ.)
 N-Fluor-bis(trifluormethyl)-amin (germ.)
 N-Fluor-N-trifluormethoxy-perfluormethylamin (germ.)
 fluoroformyl cyanide
 1-chloro-1-fluoro-ethene//1-Chlor-1-fluor-aethen//1-chloro-1-fluoroethylene
 1,1-Difluoroethene
 #trans!-1,2-difluoro-ethene//#trans!-vinylene difluoride//(E)-1,2-difluoroethylene//(E)-1,2-difluoro-ethene//#trans!-vinylene fluoride
 1,2-difluoro-ethene//#cis!-vinylene difluoride//1,2-Difluor-aethen//vinylene fluoride
 #cis!-1,2-difluoro-ethene//#cis!-vinylene difluoride//(Z)-1,2-difluoroethylene//(Z)-1,2-difluoro-ethene//#cis!-vinylene fluoride
 1,1,1,2-Tetrafluoroethane
 1,1,2,2-Tetrafluoroethane
 Fluoroethene
 1,1,1-Trifluoroethane
 Ether, methyl trifluoromethyl
 Ethene
 1,1-Difluoroethane
 Fluoroethane
 Ethane
 fluoro-dimethyl-borane
 Disiloxane, 1,1,3,3-tetrafluoro-1,3-dimethyl-
 Trifluoroethene
 trifluoroacetaldehyde//Trifluor-acetaldehyd
 Pentafluoroethane
 Difluoromethyl trifluoromethyl ether
 Tris(trifluoromethyl)bismuth
 tetrafluoropropadiene//tetrafluoro-allene//1,1,3,3-tetrafluoro-1,2-propadiene
 tetrafluorocyclopropene
 Perfluoropropionylidid
 pentafluoro-propionitrile//pentafluoropropionitrile
 hexafluoro-cyclopropane//Hexafluor-cyclopropan//freon-#C!216
 Hexafluoropropylene
 hexafluoro-[1,3]dioxolane
 Octafluoropropane
 Perfluormethylethylether
 1,1-difluoro-propadiene//allenylidene difluoride//1,1-difluoro-allene
 2,3,3,3-tetrafluoro-propene//HFO-1234yf
 trans HFO-1234ze
 3,3,3-Trifluoropropene

cyclopropene
 Allene
 1,1-difluoro-propene//propenylidene difluoride//1,1-Difluor-propen
 methylketene
 2-fluoropropene
 1-Propene
 DL-2-aminopropanoic acid
 3,3,3-trifluoro-propyne//3,3,3-Trifluor-propin//trifluoromethyl-ethyne//3,3,3-
 trifluoro-1-propyne
 1,1,3,3,3-pentafluoro-propene//1,1,3,3,3-Pentafluor-propen
 1,2,3,3,3-pentafluoro-propene
 1,1,1,4,4,4-hexafluoro-2-butyne
 1,1,4,4-tetrafluoro-butane-2,3-dione
 Trifluormethylhypochlorit
 Chlor-difluor-methyl-hypofluorit
 N-Chlor-N-fluor-trifluormethylamin (germ.)
 Chlordifluordifluoraminoethan
 thiocarbonyl difluoride
 Thiocarbonyldifluorid (germ.)
 selenocarbonyl difluoride
 Trifluoroiodomethane
 N-Fluor-difluormethanimin (germ.)
 trifluoro-nitroso-methane//Trifluor-nitroso-methan
 difluoro-carbamoyl fluoride
 trifluoro-nitro-methane//Trifluor-nitro-methan//fluoropicrin
 Tetrafluoromethane
 Tetrafluorformamidin (germ.)
 tetrafluorourea
 hypofluorous acid trifluoromethyl ester//Hypofluorigsaeure-
 trifluormethylester//trifluoromethyl hypofluorite
 trifluoromethanesulfonyl fluoride
 N,N-Difluor-trifluormethylamin (germ.)
 Trifluormethyloxydifluoramin
 (Difluoraminoxy)difluormethylhypofluorit
 sulfurcyanide pentafluoride
 Schwefelcyanid-pentafluorid (germ.)
 difluoro-trifluoromethyl-phosphine
 Hexafluormethandiamin
 perfluoro methyl silane
 Perfluormethylsilan (germ.)
 Trifluormethyl-tetrafluorphosphoran (germ.)
 Difluoromethane
 Fluoroiodomethane
 fluoromethane//methyl fluoride//Fluor-methan//freon-41
 trifluoromethyl-silane" CF₃SiH₃

methyltrifluorosilane
difluoro-methyl-silane
fluoro-methyl-silane
methylgermane
Difluorformimin
Trifluoromethane
trifluoromethane thiol
Trifluormethanthiol (germ.)
N,N,1,1-Tetrafluormethylamin
difluoro dichlorosilane
Difluordichlorsilan (germ.)
difluoro chlorosilane
Difluorchlorsilan (germ.)
Phosphorus chloride difluoride
Chlorotrifluorosilane
Hydrogen chloride
Chlorosilane
Carbon monoxide
Carbon dioxide
Carbonyl sulfide
Difluoramine
trans-Difluorodiazine
cis-Difluorodiazine
Thionyl fluoride
Trifluorosilane
Nitrogen trifluoride
Trifluoramine oxide
thiazyl trifluoride
Phosphorus trifluoride
Germanium(IV) fluoride
Tetrafuorosilane
Phosphorus pentafluoride
Selenium hexafluoride
Tellurium hexafluoride
fluorosilane
Nitrosyl fluoride
Fluorine nitrate
Hydrogen sulfide
Ammonia
Helium
Hydrogen iodide
Krypton
Nitrogen
Nitrous oxide
Neon

Nitrogen oxide; and
Xenon

4. The dielectric gaseous compound according to claim 1, further comprising forming an azeotrope of said dielectric gaseous compound.

5

5. The dielectric gaseous compound according to claim 1, further comprising admixing said dielectric gaseous compound with at least one gas selected from the group consisting of: nitrogen, CO₂ and N₂O.

10

6. An insulation-gas for use in electrical equipment, wherein said insulation-gas is a dielectric gaseous compound which exhibits the following properties:

a boiling point in the range between about -20°C to about -273°C;

low non-ozone depleting;

15

a GWP less than about 22,200;

chemical stability, as measured by a negative standard enthalpy of formation ($\Delta H_f < 0$);

a toxicity level such that when the dielectric gas leaks, the effective diluted concentration does not exceed its PEL; and

20

a dielectric strength greater than air.

7. The insulation-gas according to claim 6, wherein said dielectric gaseous compound is at least one compound selected from the group consisting of:

Arsenic pentafluoride

Arsine

Diboron tetrafluoride

Diborane

Perchloric acid, 2-chloro-1,1,2,2-tetrafluoroethyl ester (9CI)

Perchloric acid, 1,2,2-trichloro-1,2-difluoroethyl ester

Trifluoroacetyl chloride

trifluoromethylisocyanide (CF₃-NC)

trifluoromethyl isocyanide
trifluoro-nitroso-ethene//Trifluor-nitroso-aethen
Tetrafluoroethene
3,3,4,4-tetrafluoro-3,4-dihydro-[1,2]diazete
(Difluoramino)difluoracetonitril
Tetrafluorooxirane
Trifluoroacetyl fluoride
Perfluormethylfluorformiat
trifluoro-acetyl hypofluorite
perfluoro-2-aza-1-propene
Perfluor-2-aza-1-propen (germ.)
N-Fluor-tetrafluor-1-aethanimin (germ.)
3,3-difluoro-2-trifluoromethyl-oxaziridine
bis-trifluoromethyl-diazene//hexafluoro-#cis!-azomethane
Fluoroxypentafluoroethane
bis-trifluoromethyl peroxide
1,1-Bis(fluoroxy)tetrafluoroaethan
Hexafluorodimethyl sulfide
3-fluoro-3#H!-diazirine-3-carbonitrile
Ethyne
1,2,2-trifluoro-aziridine
Ketene
(difluoro)vinylboran
(Difluor)vinylboran (germ.)
trifluoro-vinyl-silane
Ethynylsilan
ethyl-difluor-borane
Ethyl-difluor-boran (germ.)
methyl-methylen-amine
Dimethyl ether
vinyl-silane
Dimethylsilane
Chloroethyne
fluoroethyne//fluoro-acetylene
Ethanedinitrile
tetrafluoropropyne//1,3,3,3-tetrafluoropropyne
hexafluoro-oxetane
Trifluoro(trifluoromethyl)oxirane
1,1,1,3,3,3-Hexafluoropropanone
pentafluoro-propionyl fluoride//perfluoropropionyl fluoride
Trifluoromethyl trifluorovinyl ether
1-Propyne
Cyclopropane
Propane
Trimethylborane

cyanoketene
butatriene
Cyano-bispentafluorethyl-phosphin
Trimethyl-1,1,2,2-tetrafluorethylsilan
methyl diborane
Methyldiboran (germ.)
carbonyl bromide fluoride
chloro-difluoro-nitroso-methane//Chlor-difluor-nitroso-methan
chloroperoxytrifluoromethane
carbonylchlorid-fluorid
Carbonylchloridfluorid (germ.)
3,3-difluoro-3#H!-diazirine
difluoro diazomethane
Difluordiazomethan (germ.)
Carbonyl fluoride
Difluordioxiran
difluoro-(3-fluoro-3#H!-diazirin-3-yl)-amine
trifluoromethylazide
Trifluormethylazid (germ.)
tetrafluoro-diaziridine
Fluorperoxytrifluormethan
Bis(fluoroxy)difluormethan
Trifluormethyl-phosphonylfluorid
Cyanogen fluoride
Trifluormethylphosphane (germ.)
Diazomethane
formaldehyde//Formalin
(methyl)difluoroborane
(Methyl)difluorboran (germ.)
Chloromethane
methylphosphonous acid difluoride//difluoro-methyl-phosphine
trifluoro-methoxy-silane
Methylhypofluorid
Methane
Methylsilane
#Si!-bromo-#Si!,#Si!'-methanediyl-bis-silane
#Si!-iodo-#Si!,#Si!'-methanediyl-bis-silane
Difluormethylnitrit
trifluoromethanol
Formyl fluoride
Cyanic acid
Chlorine
Chlorine fluoride
Chlorine trioxide fluoride
carbon oxide selenide//Kohlenoxidselenid

Fluorine
Difluorosilane
Fluorine oxide
fluorine peroxide
Sulfuryl fluoride
sulphur difluoride
Phosphorus trifluoride oxide
Phosphorus trifluoride sulfide
tetrafluorophosphorane
Tetrafluorohydrazine
Sulfur tetrafluoride
hexafluoro disiloxane
Hexafluorodisiloxan (germ.)
Nitryl fluoride
Hydrogen
Hydrogen selenide
Phosphorus trihydride
Germanium hydride
Silane
Tin tetrahydride
Oxygen
Ozone
Antimony monophosphide
Disilicon monophosphide
Radon
Argon
Trifluoroborane
Hydrogen bromide
Bromopentafluoroethane
Chlorotrifluoroethene
Trifluoroacetonitrile
trifluoromethyl isocyanate
trifluoromethyl thiocarbonyl fluoride
Trifluoromethylthiocarbonylfluorid (germ.)
pentafluoro-nitroso-ethane//Pentafluor-nitroso-aethan
(trifluoromethyl-carbonyl)-difluoro-amine
Hexafluoroethane
Bis-trifluoromethyl-nitroxid
bis-trifluoromethyl ether
bis(trifluoromethyl)tellurium
bis(trifluoromethyl) ditelluride
N,N-Difluor-pentafluoraethylamin (germ.)
N-Fluor-bis(trifluoromethyl)-amin (germ.)
N-Fluor-N-trifluoromethoxy-perfluormethylamin (germ.)
fluoroformyl cyanide

1-chloro-1-fluoro-ethene//1-Chlor-1-fluor-aethen//1-chloro-1-fluoroethylene
 1,1-Difluoroethene
 #trans!-1,2-difluoro-ethene//#trans!-vinylene difluoride//(E)-1,2-
 difluoroethylene//(E)-1,2-difluoro-ethene//#trans!-vinylene fluoride
 1,2-difluoro-ethene//#cis!-vinylene difluoride//1,2-Difluor-aethen//vinylene
 fluoride
 #cis!-1,2-difluoro-ethene//#cis!-vinylene difluoride//(Z)-1,2-
 difluoroethylene//(Z)-1,2-difluoro-ethene//#cis!-vinylene fluoride
 1,1,1,2-Tetrafluoroethane
 1,1,2,2-Tetrafluoroethane
 Fluoroethene
 1,1,1-Trifluoroethane
 Ether, methyl trifluoromethyl
 Ethene
 1,1-Difluoroethane
 Fluoroethane
 Ethane
 fluoro-dimethyl-borane
 Disiloxane, 1,1,3,3-tetrafluoro-1,3-dimethyl-
 Trifluoroethene
 trifluoroacetaldehyde//Trifluor-acetaldehyd
 Pentafluoroethane
 Difluoromethyl trifluoromethyl ether
 Tris(trifluoromethyl)bismuth
 tetrafluoropropadiene//tetrafluoro-allene//1,1,3,3-tetrafluoro-1,2-propadiene
 tetrafluorocyclopropene
 Perfluoropropionylidid
 pentafluoro-propionitrile//pentafluoropropionitrile
 hexafluoro-cyclopropane//Hexafluor-cyclopropan//freon-#C!216
 Hexafluoropropylene
 hexafluoro-[1,3]dioxolane
 Octafluoropropane
 Perfluormethylethylether
 1,1-difluoro-propadiene//allenylidene difluoride//1,1-difluoro-allene
 2,3,3,3-tetrafluoro-propene//HFO-1234yf
 trans HFO-1234ze
 3,3,3-Trifluoropropene
 cyclopropene
 Allene
 1,1-difluoro-propene//propenylidene difluoride//1,1-Difluor-propen
 methylketene
 2-fluoropropene
 1-Propene
 DL-2-aminopropanoic acid
 3,3,3-trifluoro-propyne//3,3,3-Trifluor-propin//trifluoromethyl-ethyne//3,3,3-

trifluoro-1-propyne
1,1,3,3,3-pentafluoro-propene//1,1,3,3,3-Pentafluor-propen
1,2,3,3,3-pentafluoro-propene
1,1,1,4,4,4-hexafluoro-2-butyne
1,1,4,4-tetrafluoro-butane-2,3-dione
Trifluormethylhypochlorit
Chlor-difluor-methyl-hypofluorit
N-Chlor-N-fluor-trifluormethylamin (germ.)
Chlordifluordifluoraminoethan
thiocarbonyl difluoride
Thiocarbonyldifluorid (germ.)
selenocarbonyl difluoride
Trifluoroiodomethane
N-Fluor-difluormethanimin (germ.)
trifluoro-nitroso-methane//Trifluor-nitroso-methan
difluoro-carbamoyl fluoride
trifluoro-nitro-methane//Trifluor-nitro-methan//fluoropicrin
Tetrafluoromethane
Tetrafluorformamidin (germ.)
tetrafluorourea
hypofluorous acid trifluoromethyl ester//Hypofluorigsaecure-
trifluormethylester//trifluoromethyl hypofluorite
trifluoromethanesulfonyl fluoride
N,N-Difluor-trifluormethylamin (germ.)
Trifluormethyloxydifluoramin
(Difluoraminoxy)difluormethylhypofluorit
sulfurcyanide pentafluoride
Schwefelcyanid-pentafluorid (germ.)
difluoro-trifluoromethyl-phosphine
Hexafluormethandiamin
perfluoro methyl silane
Perfluormethylsilan (germ.)
Trifluormethyl-tetrafluorphosphoran (germ.)
Difluoromethane
Fluoroiodomethane
fluoromethane//methyl fluoride//Fluor-methan//freon-41
trifluoromethyl-silane" CF₃SiH₃
methyltrifluorosilane
difluoro-methyl-silane
fluoro-methyl-silane
methylgermane
Difluorformimin
Trifluoromethane
trifluoromethane thiol
Trifluormethanthiol (germ.)

N,N,1,1-Tetrafluormethylamin
difluoro dichlorosilane
Difluordichlorsilan (germ.)
difluoro chlorosilane
Difluorchlorsilan (germ.)
Phosphorus chloride difluoride
Chlorotrifluorosilane
Hydrogen chloride
Chlorosilane
Carbon monoxide
Carbon dioxide
Carbonyl sulfide
Difluoramine
trans-Difluorodiazine
cis-Difluorodiazine
Thionyl fluoride
Trifluorosilane
Nitrogen trifluoride
Trifluoramine oxide
thiazyl trifluoride
Phosphorus trifluoride
Germanium(IV) fluoride
Tetrafluorosilane
Phosphorus pentafluoride
Selenium hexafluoride
Tellurium hexafluoride
fluorosilane
Nitrosyl fluoride
Fluorine nitrate
Hydrogen sulfide
Ammonia
Helium
Hydrogen iodide
Krypton
Nitrogen
dinitrogen oxide
Neon
Nitrogen oxide; and
Xenon

8. The insulation-gas according to claim 7, wherein said dielectric gaseous compound is at least one compound selected from the group consisting of:

Argon
 Trifluoroborane
 Hydrogen bromide
 Bromopentafluoroethane
 Chlorotrifluoroethene
 Trifluoroacetonitrile
 trifluoromethyl isocyanate
 trifluoromethyl thiocarbonyl fluoride
 Trifluormethylthiocarbonylfluorid (germ.)
 pentafluoro-nitroso-ethane//Pentafluor-nitroso-aethan
 (trifluoromethyl-carbonyl)-difluoro-amine
 Hexafluoroethane
 Bis-trifluormethyl-nitroxid
 bis-trifluoromethyl ether
 bis(trifluoromethyl)tellurium
 bis(trifluoromethyl) ditelluride
 N,N-Difluor-pentafluoraethylamin (germ.)
 N-Fluor-bis(trifluormethyl)-amin (germ.)
 N-Fluor-N-trifluormethoxy-perfluormethylamin (germ.)
 fluoroformyl cyanide
 1-chloro-1-fluoro-ethene//1-Chlor-1-fluor-aethen//1-chloro-1-fluoroethylene
 1,1-Difluoroethene
 #trans!-1,2-difluoro-ethene//#trans!-vinylene difluoride//(E)-1,2-
 difluoroethylene//(E)-1,2-difluoro-ethene//#trans!-vinylene fluoride
 1,2-difluoro-ethene//#cis!-vinylene difluoride//1,2-Difluor-aethen//vinylene
 fluoride
 #cis!-1,2-difluoro-ethene//#cis!-vinylene difluoride//(Z)-1,2-
 difluoroethylene//(Z)-1,2-difluoro-ethene//#cis!-vinylene fluoride
 1,1,1,2-Tetrafluoroethane
 1,1,2,2-Tetrafluoroethane
 Fluoroethene
 1,1,1-Trifluoroethane
 Ether, methyl trifluoromethyl
 Ethene
 1,1-Difluoroethane
 Fluoroethane
 Ethane
 fluoro-dimethyl-borane
 Disiloxane, 1,1,3,3-tetrafluoro-1,3-dimethyl-
 Trifluoroethene
 trifluoroacetaldehyde//Trifluor-acetaldehyd
 Pentafluoroethane

Difluoromethyl trifluoromethyl ether
 Tris(trifluoromethyl)bismuth
 tetrafluoropropadiene//tetrafluoro-allene//1,1,3,3-tetrafluoro-1,2-propadiene
 tetrafluorocyclopropene
 Perfluoropropionylidid
 pentafluoro-propionitrile//pentafluoropropionitrile
 hexafluoro-cyclopropane//Hexafluor-cyclopropan//freon-#C!216
 Hexafluoropropylene
 hexafluoro-[1,3]dioxolane
 Octafluoropropane
 Perfluormethylethylether
 1,1-difluoro-propadiene//allenylidene difluoride//1,1-difluoro-allene
 2,3,3,3-tetrafluoro-propene//HFO-1234yf
 trans HFO-1234ze
 3,3,3-Trifluoropropene
 cyclopropene
 Allene
 1,1-difluoro-propene//propenylidene difluoride//1,1-Difluor-propen
 methylketene
 2-fluoropropene
 1-Propene
 DL-2-aminopropanoic acid
 3,3,3-trifluoro-propyne//3,3,3-Trifluor-propin//trifluoromethyl-ethyne//3,3,3-
 trifluoro-1-propyne
 1,1,3,3,3-pentafluoro-propene//1,1,3,3,3-Pentafluor-propen
 1,2,3,3,3-pentafluoro-propene
 1,1,1,4,4,4-hexafluoro-2-butyne
 1,1,4,4-tetrafluoro-butane-2,3-dione
 Trifluormethylhypochlorit
 Chlor-difluor-methyl-hypofluorit
 N-Chlor-N-fluor-trifluormethylamin (germ.)
 Chlordifluordifluoraminoethan
 thiocarbonyl difluoride
 Thiocarbonyldifluorid (germ.)
 selenocarbonyl difluoride
 Trifluoroiodomethane
 N-Fluor-difluormethanimin (germ.)
 trifluoro-nitroso-methane//Trifluor-nitroso-methan
 difluoro-carbamoyl fluoride
 trifluoro-nitro-methane//Trifluor-nitro-methan//fluoropicrin
 Tetrafluoromethane
 Tetrafluorformamidin (germ.)
 tetrafluorourea
 hypofluorous acid trifluoromethyl ester//Hypofluorigsaeure-
 trifluormethylester//trifluoromethyl hypofluorite

trifluoromethanesulfonyl fluoride
N,N-Difluor-trifluormethylamin (germ.)
Trifluormethoxydifluoramin
(Difluoraminoxy)difluormethylhypofluorit
sulfurcyanide pentafluoride
Schwefelcyanid-pentafluorid (germ.)
difluoro-trifluoromethyl-phosphine
Hexafluormethandiamin
perfluoro methyl silane
Perfluormethylsilan (germ.)
Trifluormethyl-tetrafluorphosphoran (germ.)
Difluoromethane
Fluoriodomethane
fluoromethane//methyl fluoride//Fluor-methan//freon-41
trifluoromethyl-silane" CF₃SiH₃
methyltrifluorosilane
difluoro-methyl-silane
fluoro-methyl-silane
methylgermane
Difluorformimin
Trifluoromethane
trifluoromethane thiol
Trifluormethanthiol (germ.)
N,N,1,1-Tetrafluormethylamin
difluoro dichlorosilane
Difluordichlorsilan (germ.)
difluoro chlorosilane
Difluorchlorsilan (germ.)
Phosphorus chloride difluoride
Chlorotrifluorosilane
Hydrogen chloride
Chlorosilane
Carbon monoxide
Carbon dioxide
Carbonyl sulfide
Difluoramine
trans-Difluorodiazine
cis-Difluorodiazine
Thionyl fluoride
Trifluorosilane
Nitrogen trifluoride
Trifluoramine oxide
thiazyl trifluoride
Phosphorus trifluoride
Germanium(IV) fluoride

Tetrafluorosilane
Phosphorus pentafluoride
Selenium hexafluoride
Tellurium hexafluoride
fluorosilane
Nitrosyl fluoride
Fluorine nitrate
Hydrogen sulfide
Ammonia
Helium
Hydrogen iodide
Krypton
Nitrogen
Nitrous oxide
Neon
Nitrogen oxide; and
Xenon

9. The insulation-gas according to claim 6, further comprising forming an azeotrope of said dielectric gaseous compound.

5

10. The insulation-gas according to claim 6, further comprising admixing said dielectric gaseous compound with at least one gas selected from the group consisting of: nitrogen, CO₂ and N₂O.

10 11. The insulation-gas according to claim 6, wherein said electrical equipment is at least one selected from the group consisting of: gas-insulated circuit breakers and current-interruption equipment, gas-insulated transmission lines, gas-insulated transformers, and gas-insulated substations.

15